

Electron interference effects in cuprate superconductor/graphene junctions

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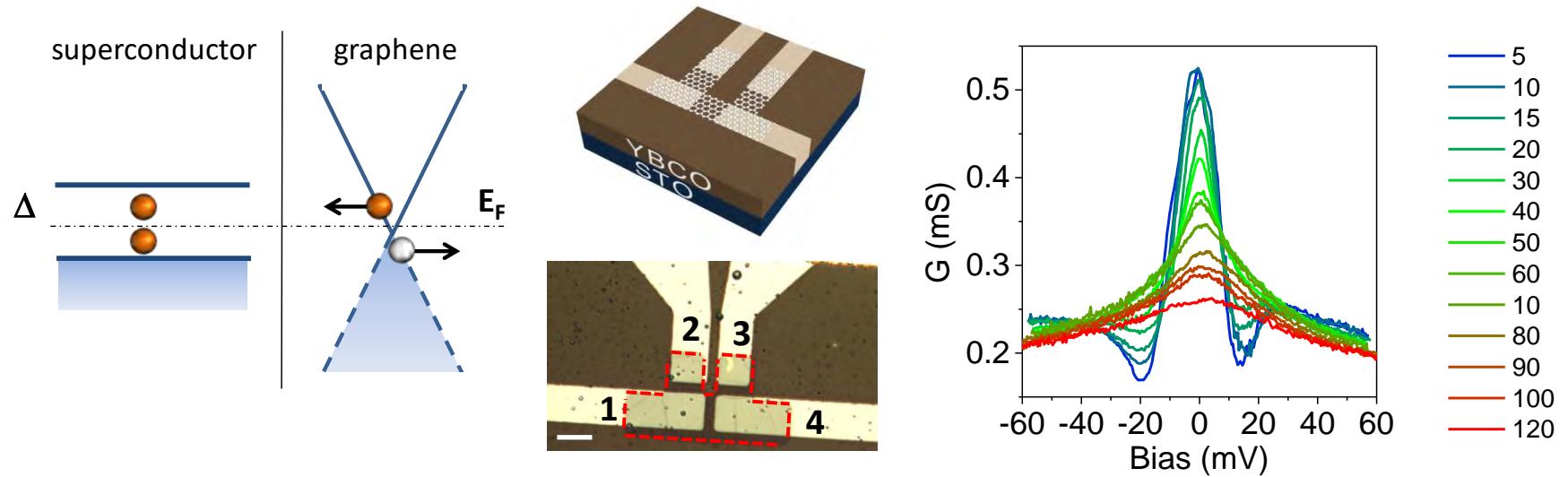


Agence Nationale de la Recherche
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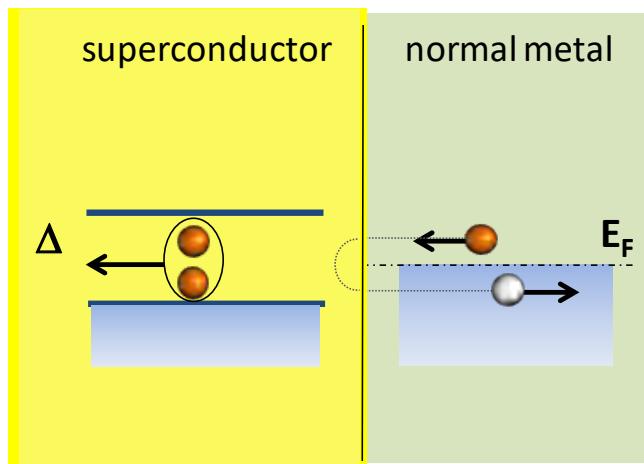
Outline

Electron interferences at high- T_c S/graphene interfaces



→ KLEIN TUNNELING OF HIGH- T_c PAIRS
→ ELECTROSTATIC CONTROL

Proximity effect mechanism: Andreev reflection

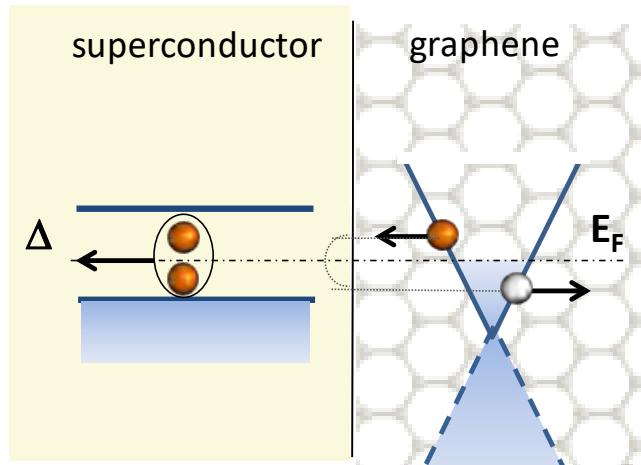


$$\xi_N = \frac{\hbar v_F}{2\pi kT} \quad \text{ballistic}$$

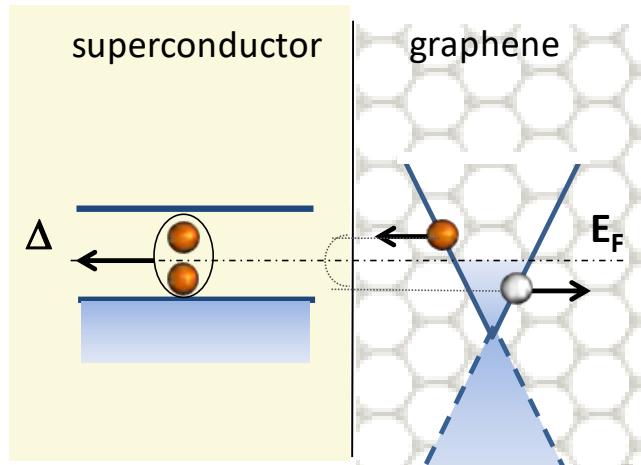
$$\xi_N = \sqrt{\frac{\hbar D}{2\pi kT}} \quad \text{diffusive}$$

- ELECTRON/HOLE SUPERCONDUCTING PAIRS
- METAL BECOMES SUPERCONDUCTING OVER ξ

Band structure affects proximity effect

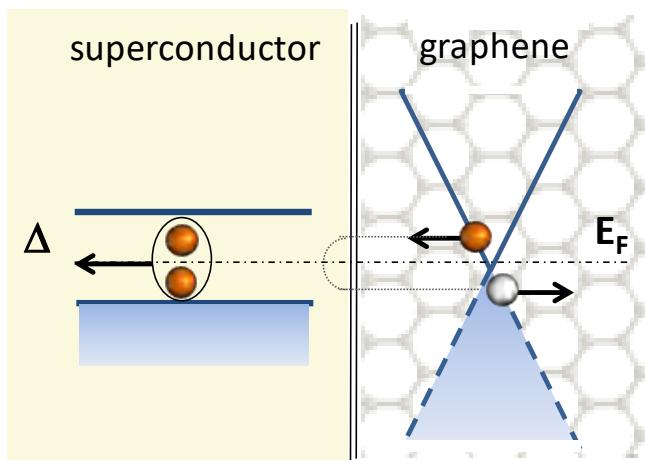


Band structure affects proximity effect



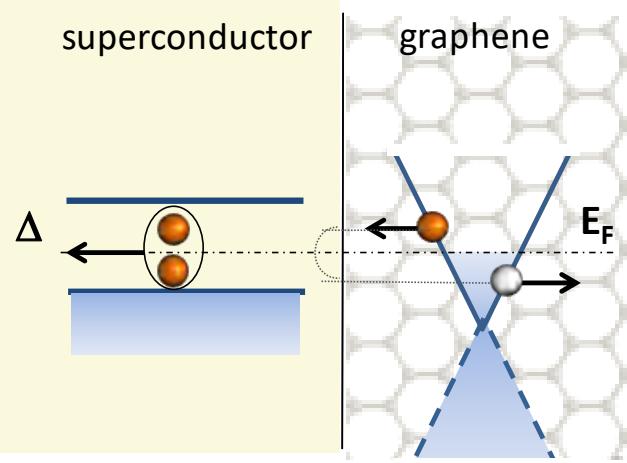
→ INTRA-BAND OR INTER-BAND PROCESS:
TUNABLE BY DOPING

C.W.J. Beenakker PRL 97 067007, (2006)



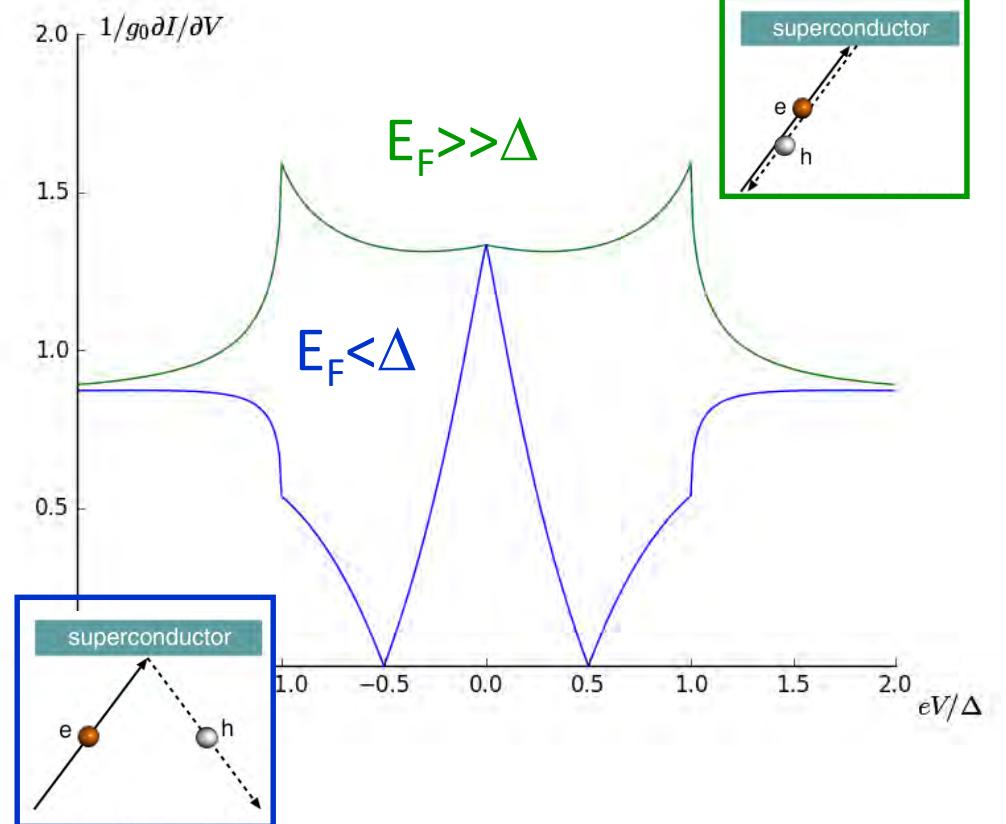
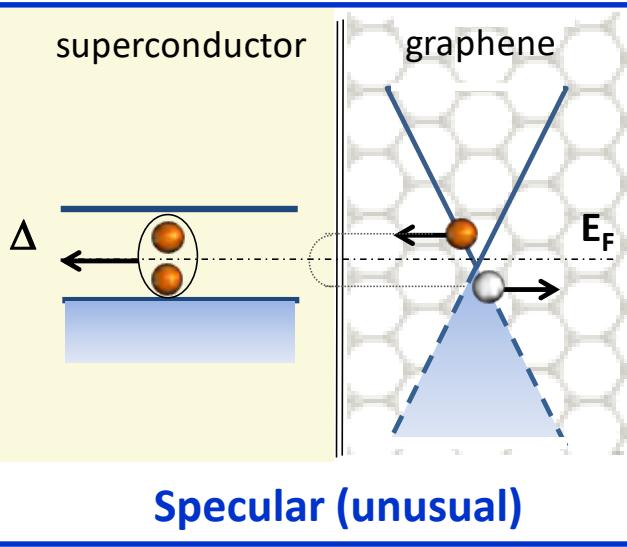
Band structure affects proximity effect

Retroreflection (conventional)

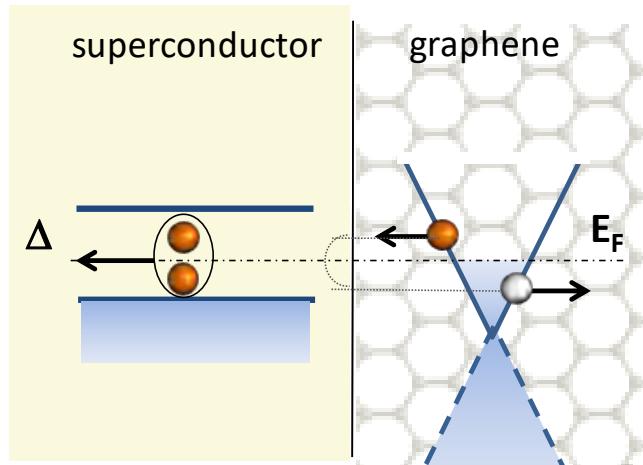


→ INTRA-BAND OR INTER-BAND PROCESS:
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C.W.J. Beenakker PRL 97 067007, (2006)



Band structure affects proximity effect

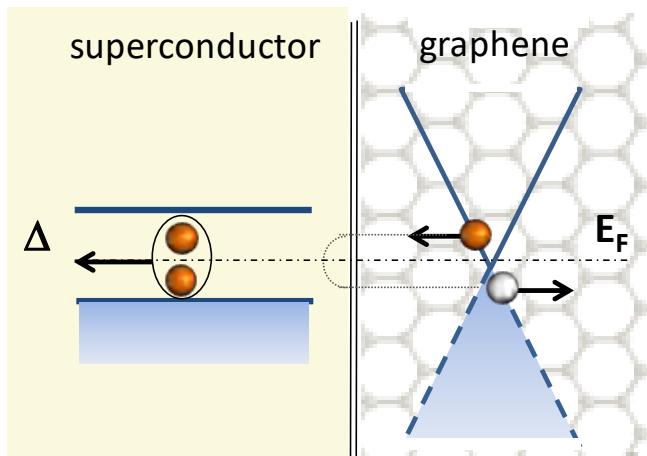


→ INTRA-BAND OR INTER-BAND PROCESS:
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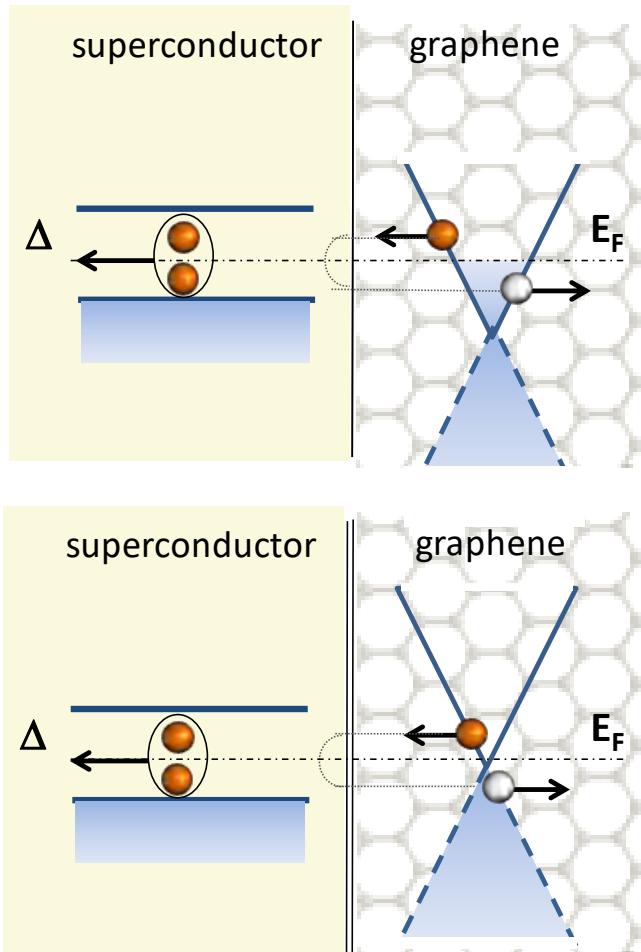
C.W.J. Beenakker PRL 97 067007, (2006)

$$E(K) = \hbar v_F K$$

→ LINEAR DISPERSION: WAVE-VECTOR
INDEPENDENT VELOCITY



Band structure affects proximity effect



→ INTRA-BAND OR INTER-BAND PROCESS:
TUNABLE BY DOPING

C.W.J. Beenakker PRL 97 067007, (2006)

$$E(K) = \hbar v_F K$$

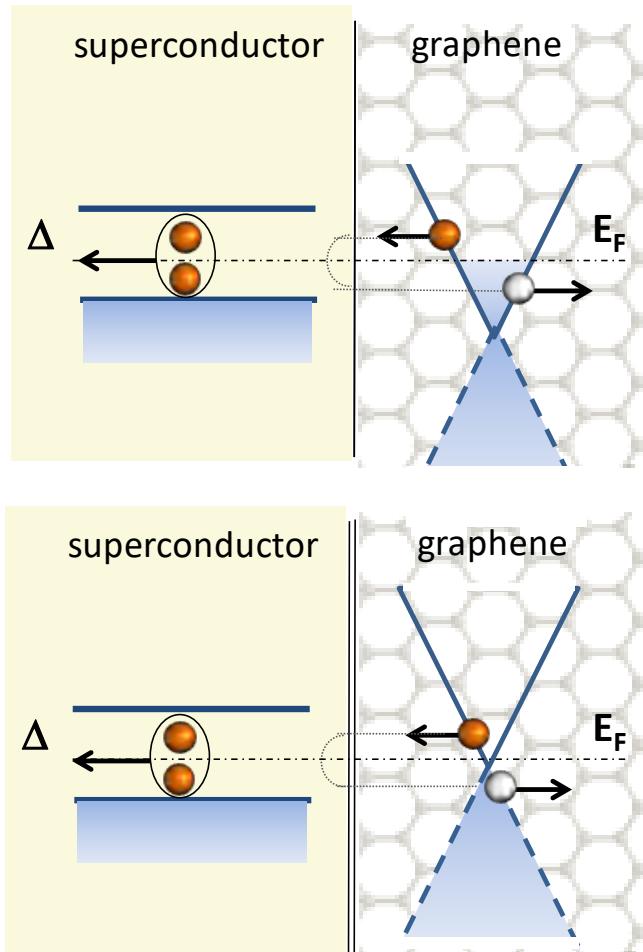
→ LINEAR DISPERSION: WAVE-VECTOR
INDEPENDENT VELOCITY

→ LOW CARRIER DENSITY

→ NEW PHYSICS

→ POSSIBILITIES ABSENT IN ORDINARY JOSEPHSON JUNCTIONS

Band structure affects proximity effect



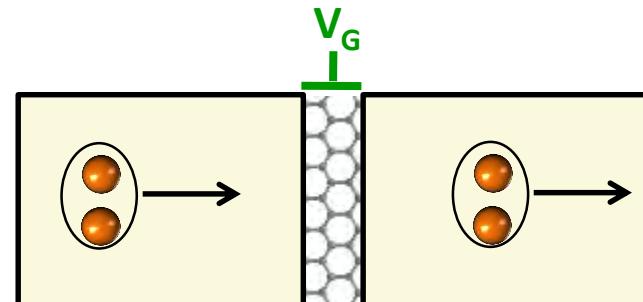
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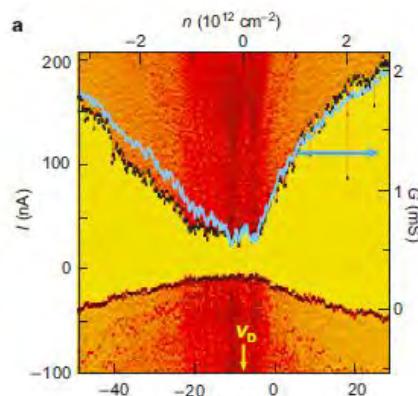
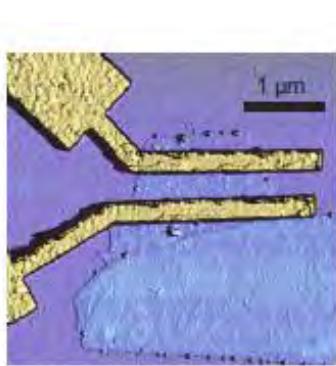


→ GATE TUNABLE JOSEPHSON JUNCTIONS

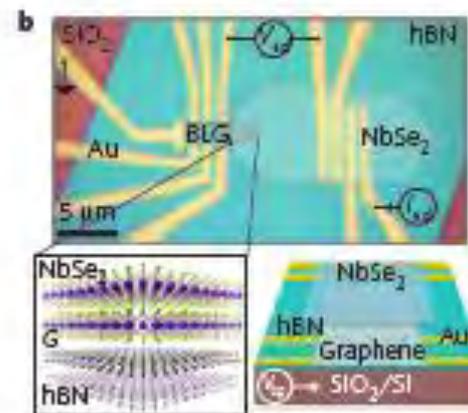
→ NEW PHYSICS

→ POSSIBILITIES ABSENT IN ORDINARY JOSEPHSON JUNCTIONS

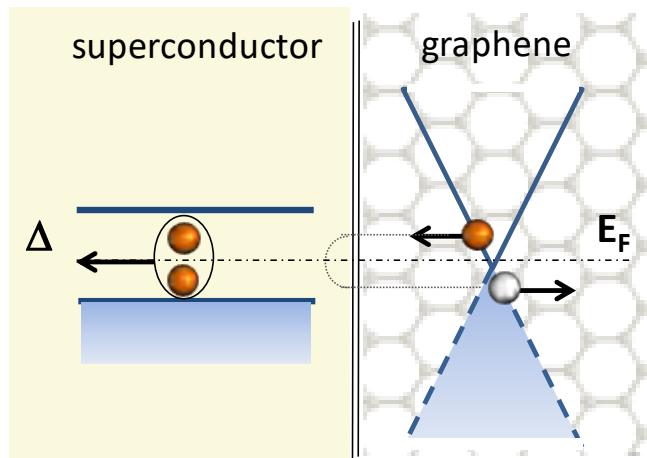
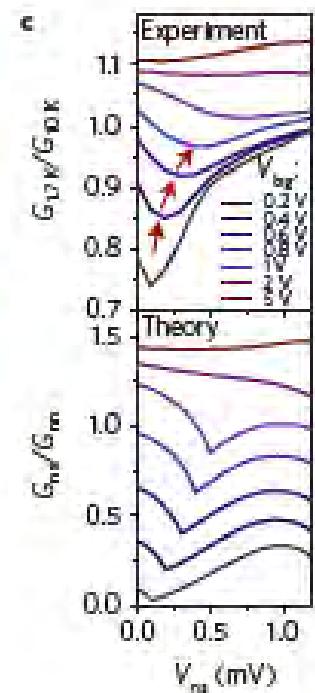
Experiments with low- T_c superconductors



Heersche *et al.* Nature (2007)



Efetov *et al.* Nat. Phys. (2015)



→ E_F INHOMOGENEITY MUST BE SMALLER THAN SUPERCONDUCTING GAP Δ !!!!

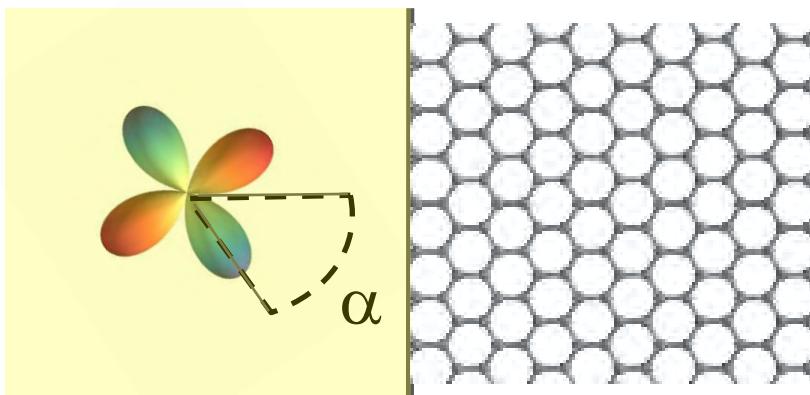
→ LIMITED TO LOW TEMPERATURES ($\sim 1\text{K}$)

→ PRISTINE EFFECTS ONLY WITH ULTRA-CLEAN GRAPHENE

Motivation for high- T_c superconductor/graphene

superconductor

graphene



→ DIRECTIONAL EFFECTS
DUE TO D-WAVE SYMMETRY

Linder *et al.* PRB (2008)

SUPERCONDUCTING GAP $\Delta \sim 10\text{-}30$ meV
INSTEAD OF $\Delta \sim 1$ meV

→ SUPERCONDUCTING EFFECTS ROBUST AGAINST
GRAPHENE INHOMOGENEITIES

Recent work on high- T_c /graphene

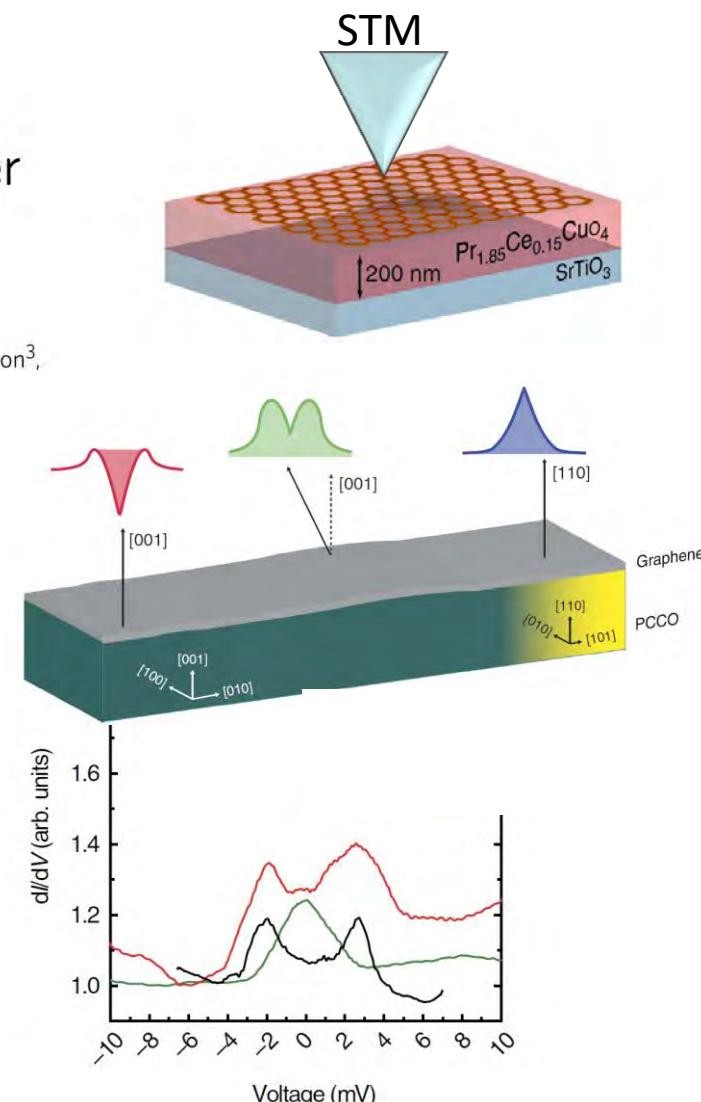
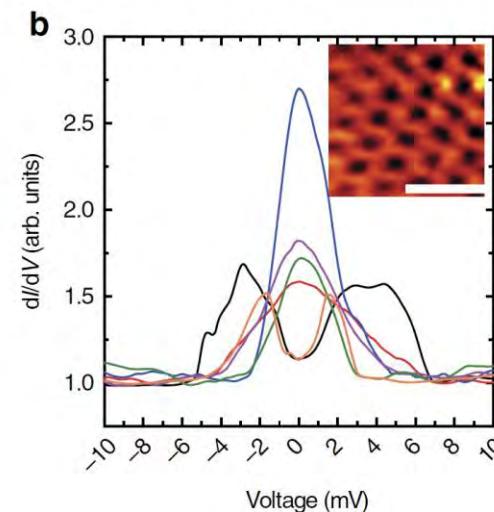
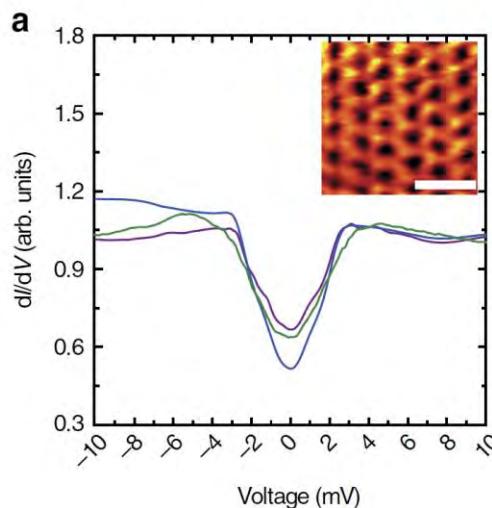


DOI: 10.1038/ncomms14024

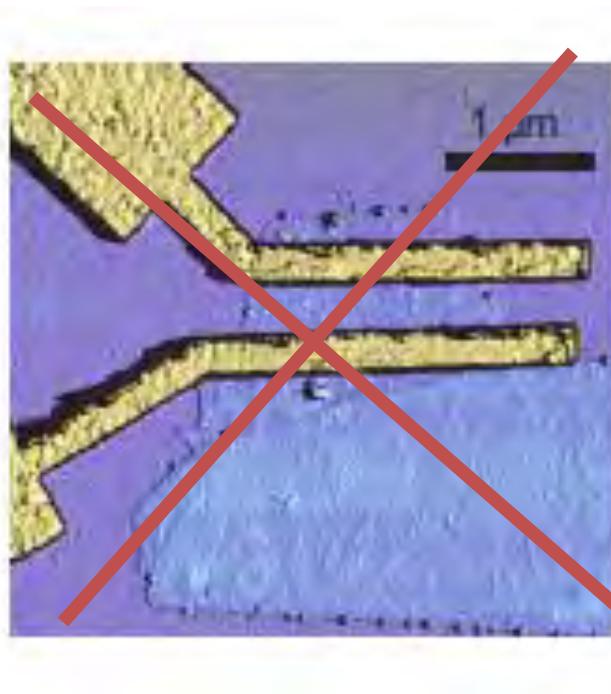
OPEN

p -wave triggered superconductivity in single-layer graphene on an electron-doped oxide superconductor

A. Di Bernardo¹, O. Millo², M. Barbone³, H. Alpern², Y. Kalcheim², U. Sassi^{3,†}, A.K. Ott³, D. De Fazio³, D. Yoon³, M. Amado¹, A.C. Ferrari³, J. Linder⁴ & J.W.A. Robinson¹



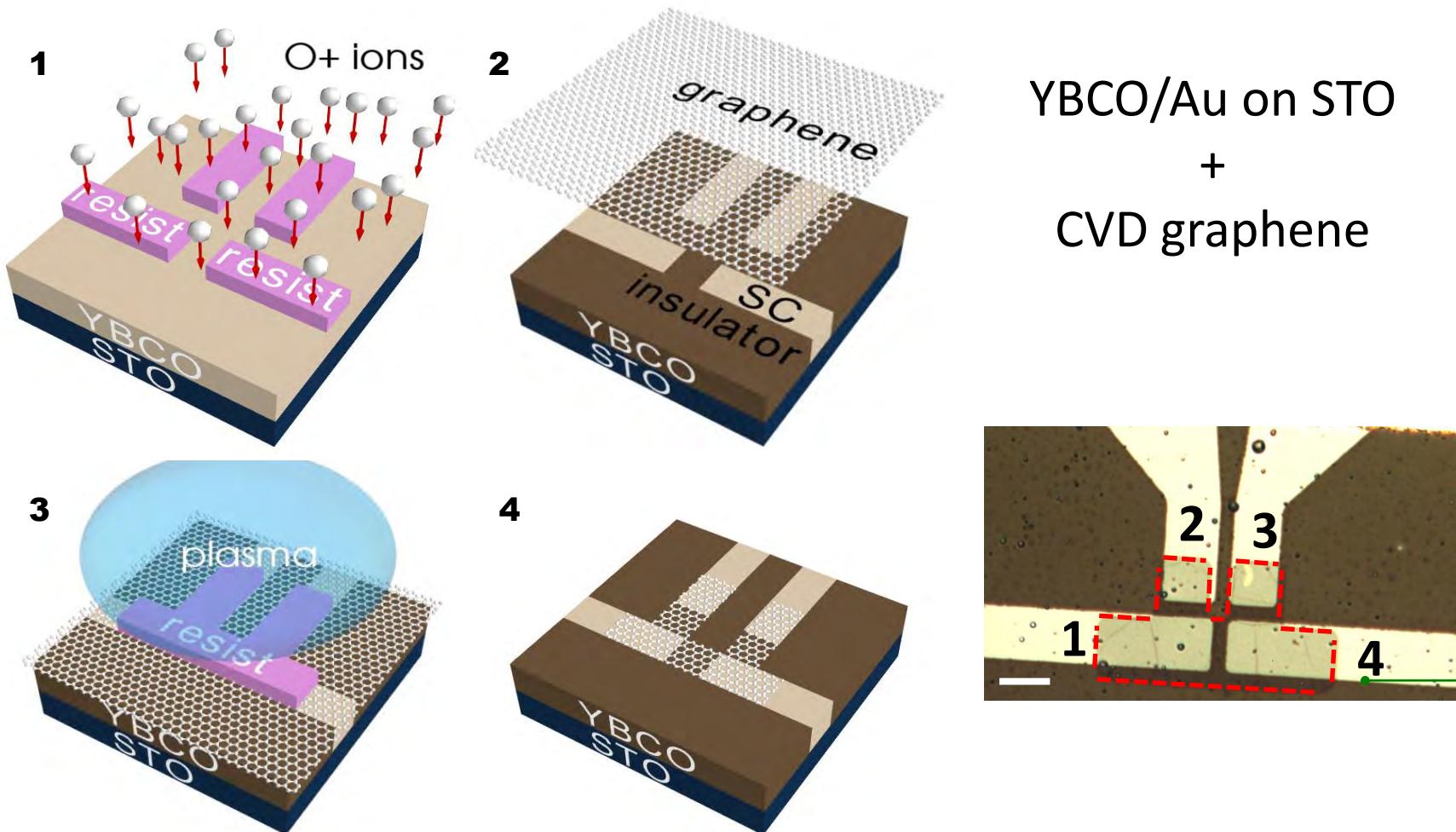
high- T_c superconductor/graphene “complications”



-DEPOSITION OF OXIDE SUPERCONDUCTOR ON GRAPHENE NOT POSSIBLE
- OXIDE SUPERCONDUCTOR PRONE TO DEGRADATION

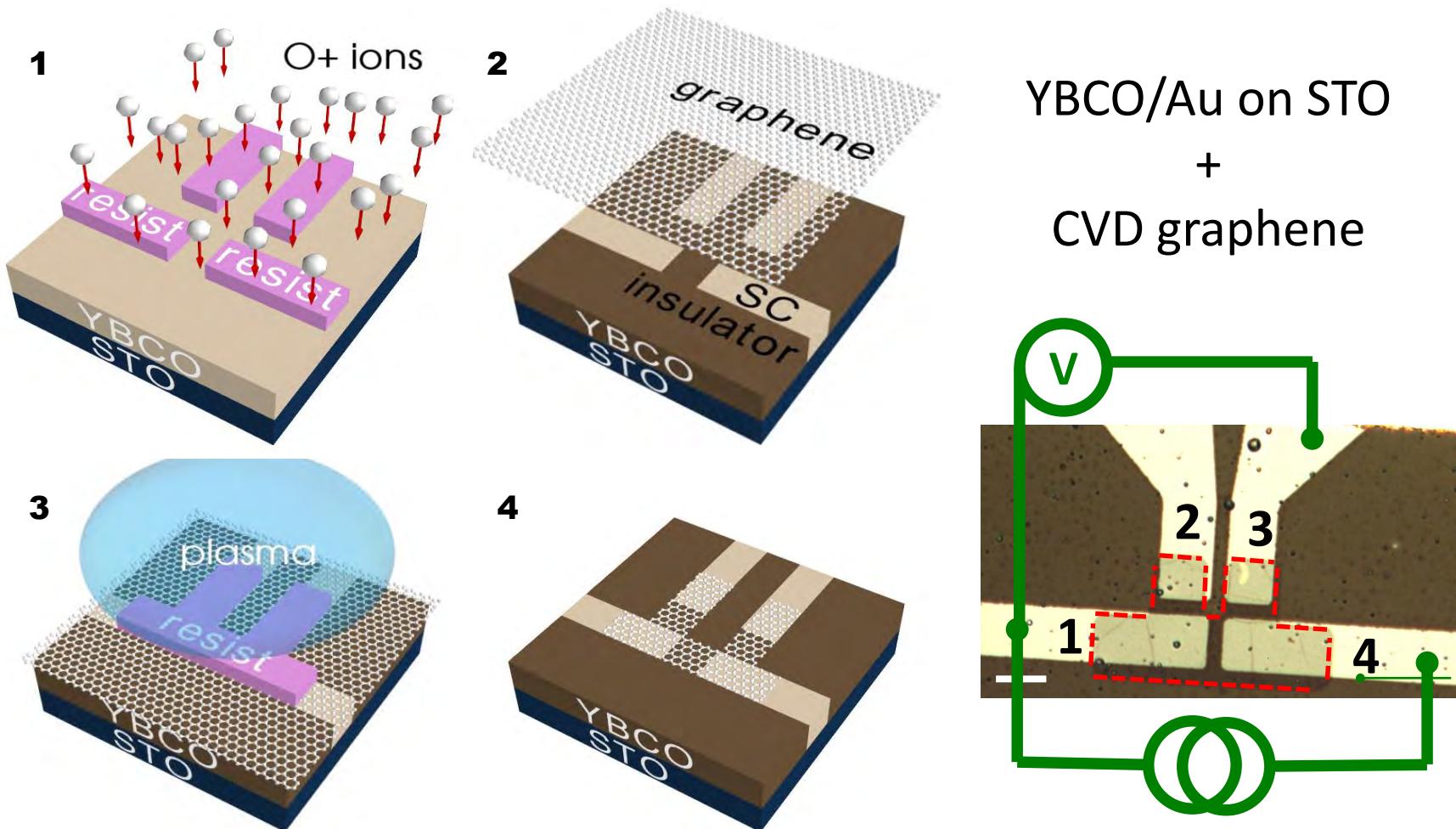
→ NEW FABRICATION APPROACH REQUIRED

high- T_c superconductor/graphene devices



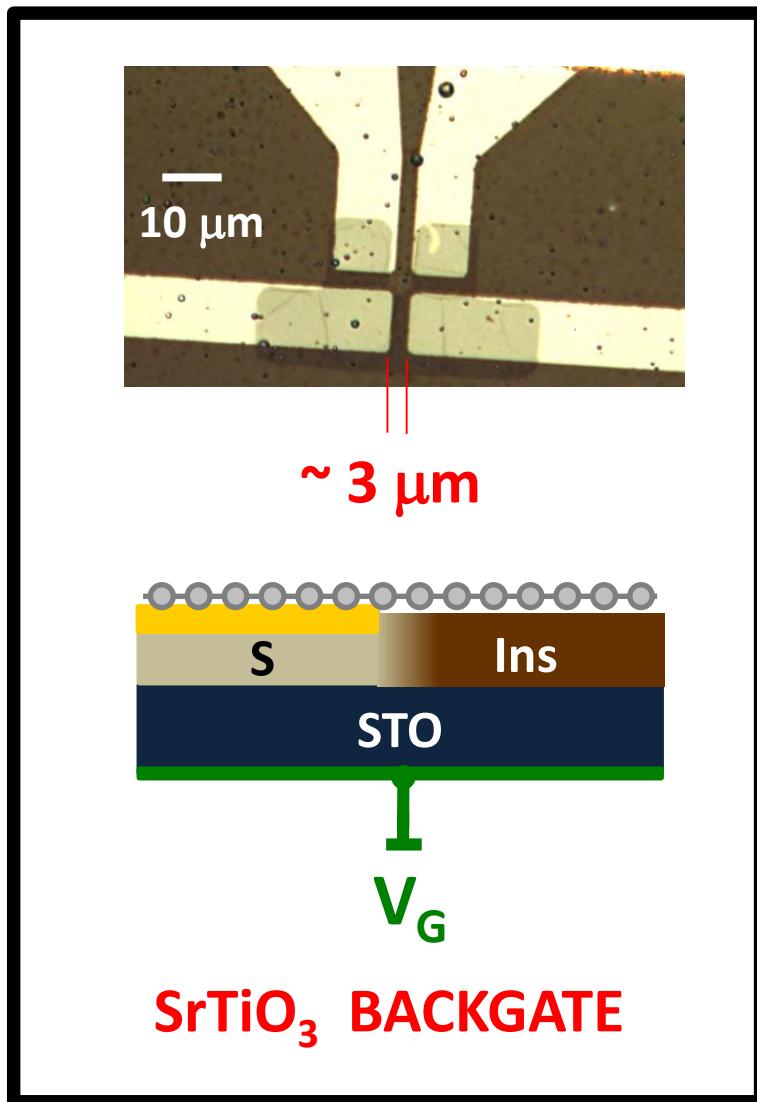
→ ION IRRADIATION TO DEFINE PLANAR DEVICE

high- T_c superconductor/graphene devices

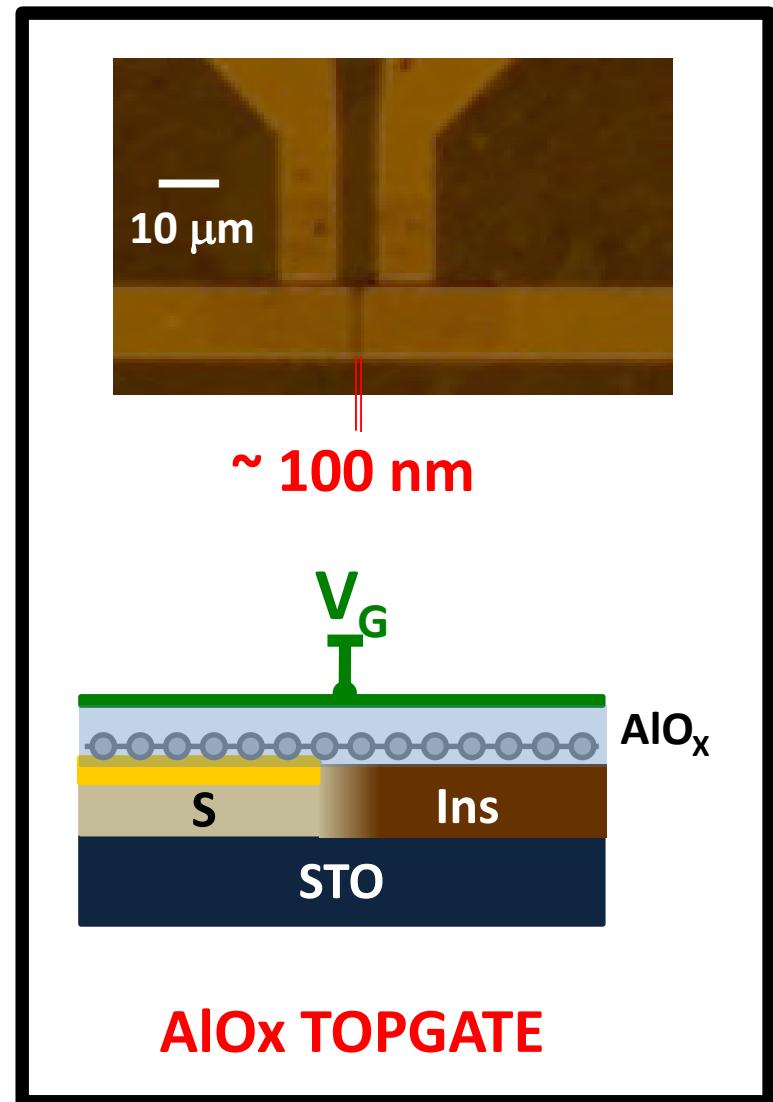


→ ION IRRADIATION TO DEFINE PLANAR DEVICE

Two different devices studied

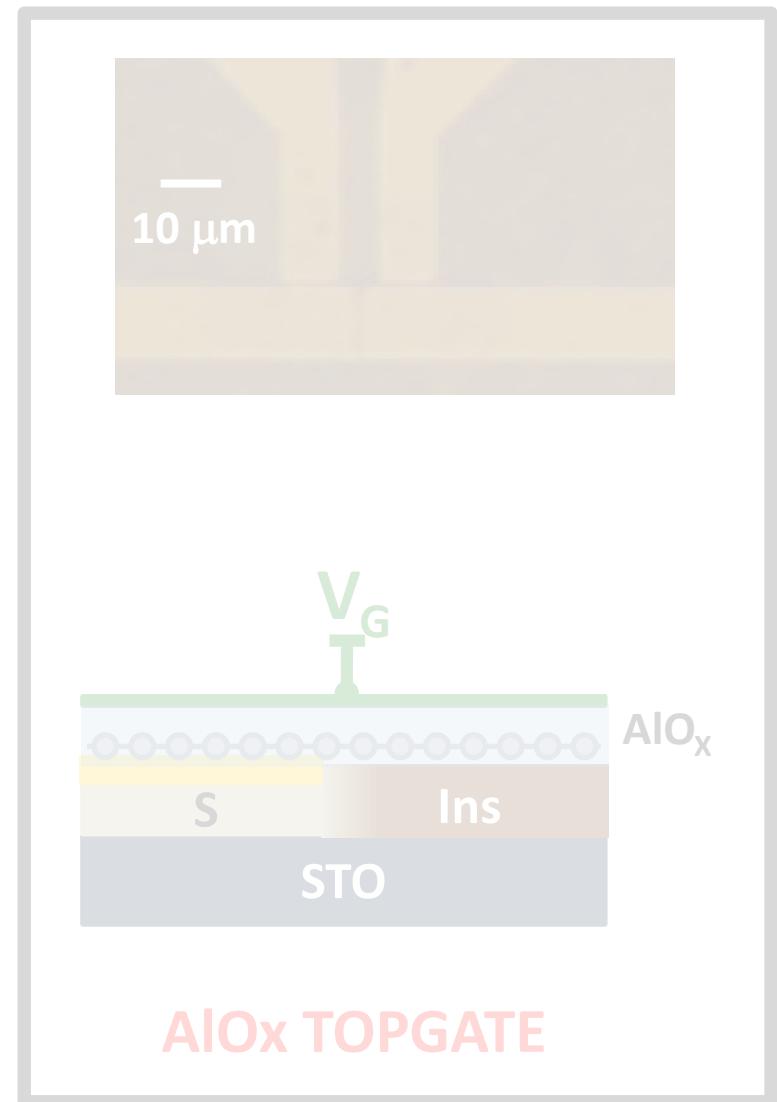
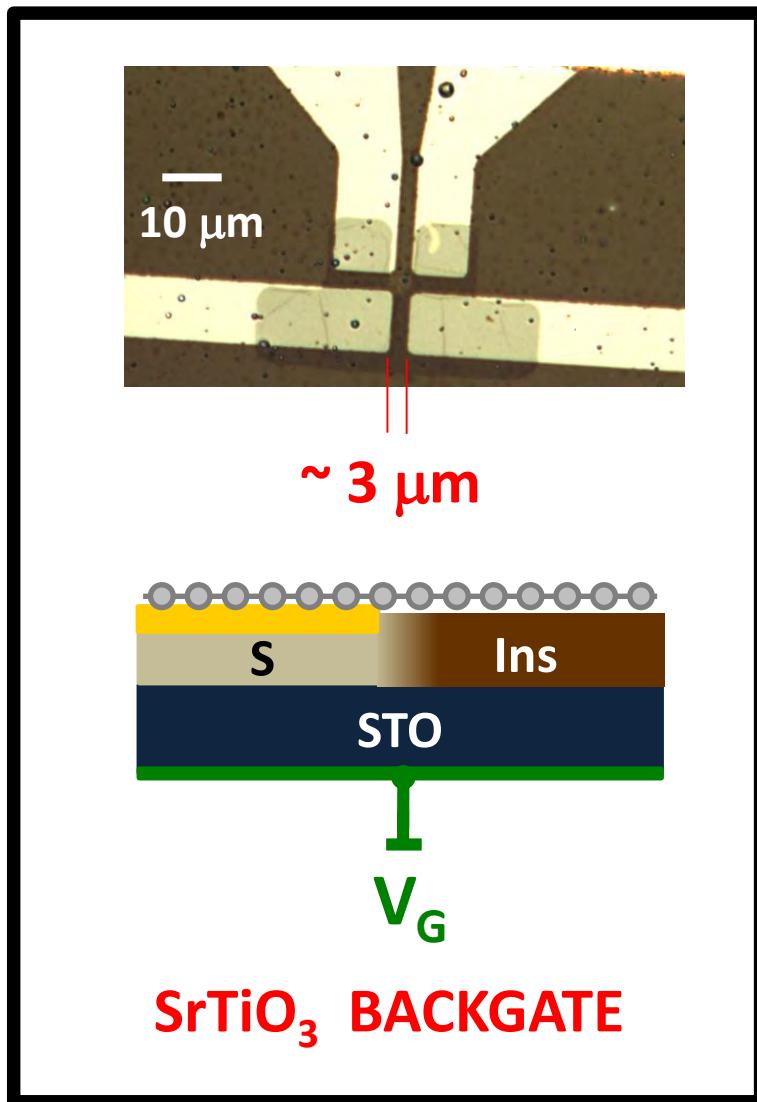


SrTiO_3 BACKGATE

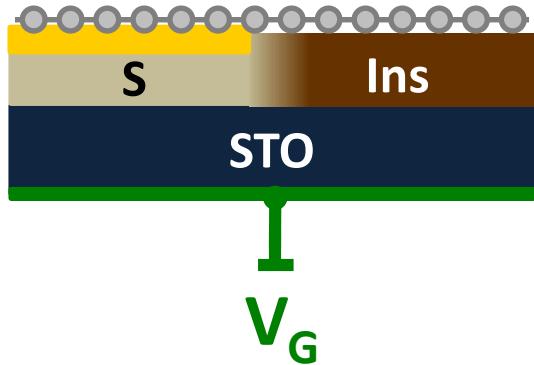


AlO_x TOPGATE

Two different devices studied

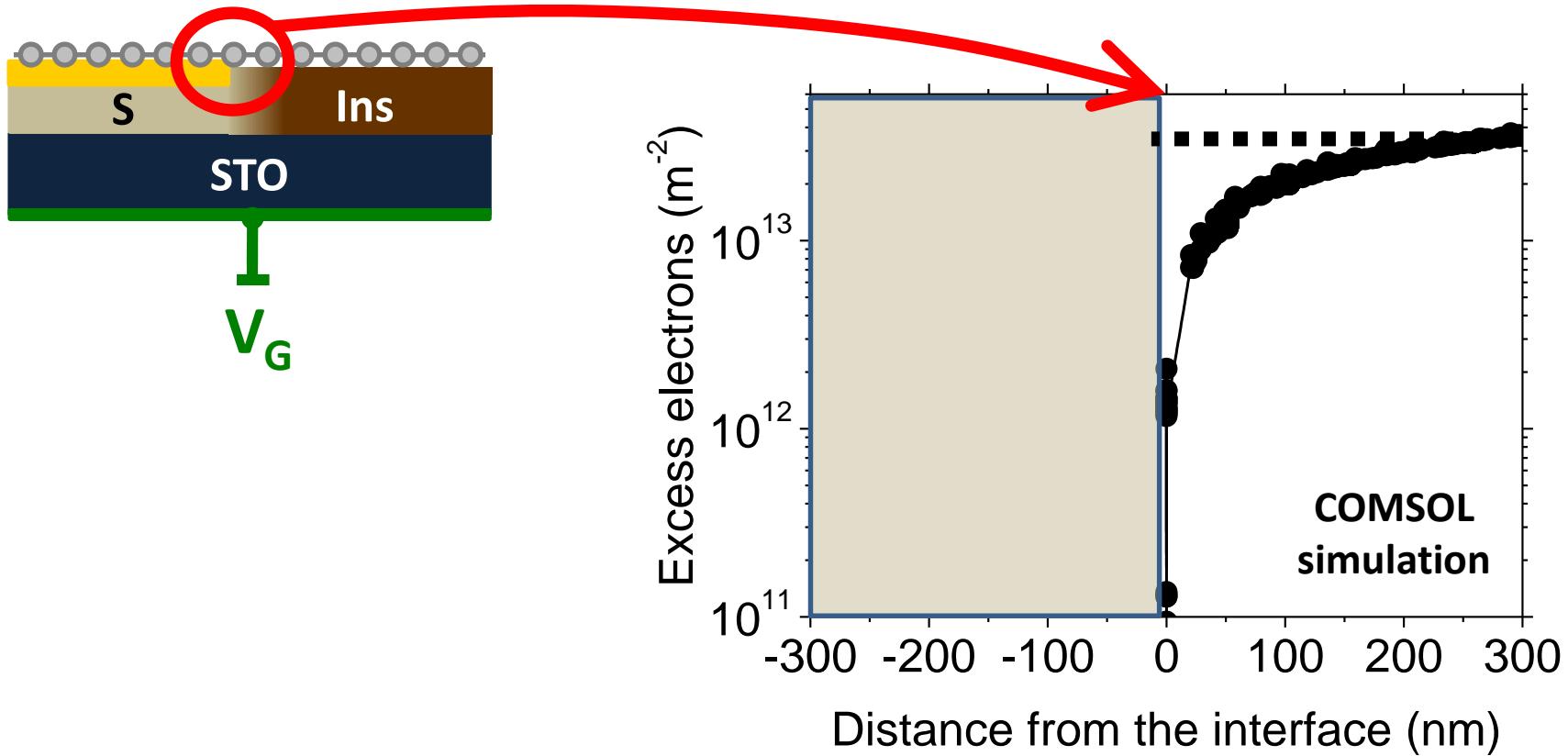


SrTiO₃ backgate properties



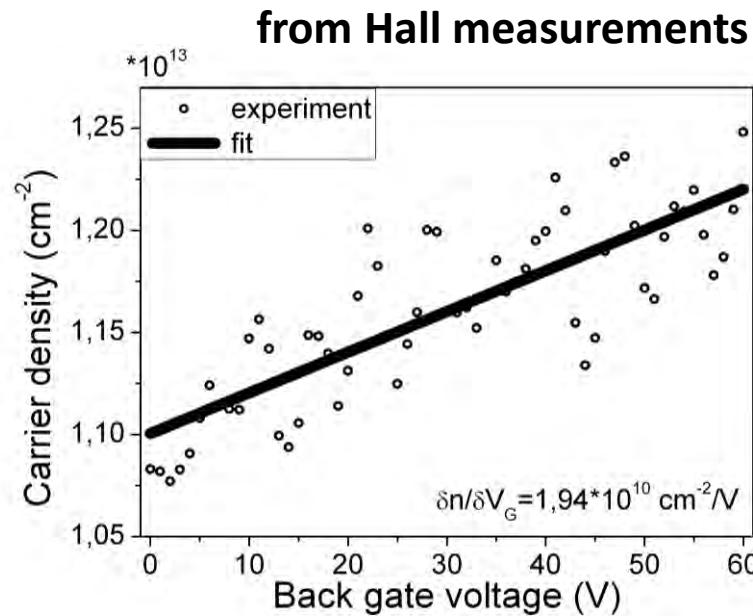
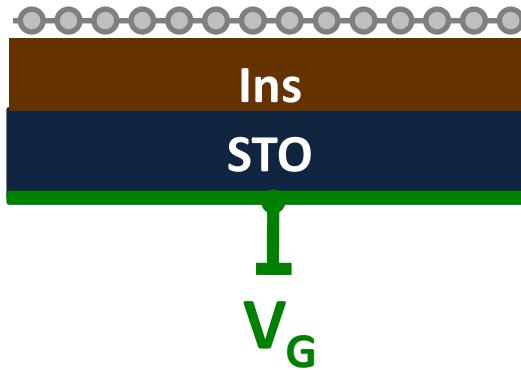
→ **ONLY GRAPHENE ON INSULATOR IS DOPED**

SrTiO₃ backgate properties



- ONLY GRAPHENE ON INSULATOR IS DOPED
- FRINGE FIELDS: INHOMOGENEOUS DOPING

SrTiO₃ backgate properties

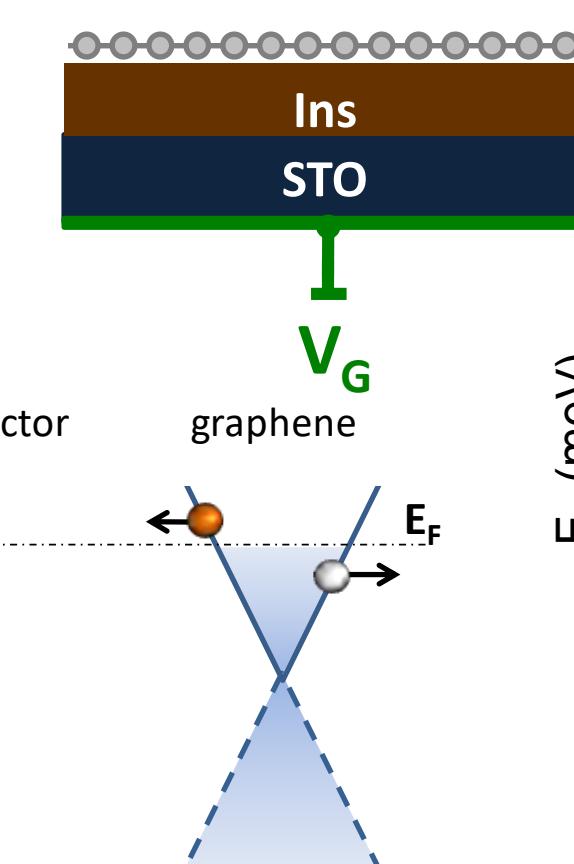


$$n = \frac{1}{e} \frac{\partial B}{\partial R_{xy}} \sim 10^{13} \text{ cm}^{-2}$$

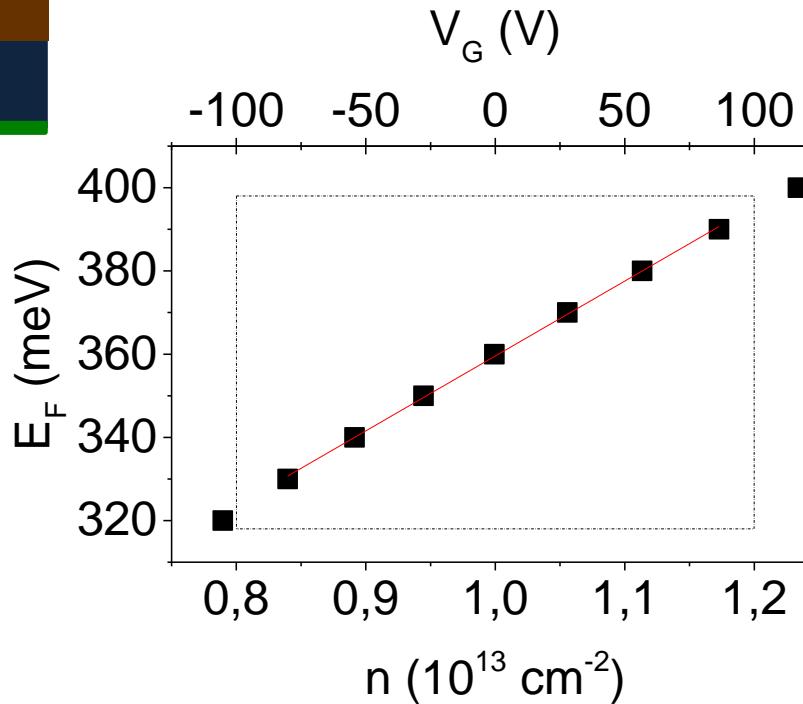
$$E_F = \hbar v_F k = \hbar v_F \sqrt{\pi n}$$

- DOPING PROPORTIONAL TO V_G
- HIGH NATIVE DOPING $\sim 10^{13} \text{ cm}^{-2}$

SrTiO₃ backgate properties



from Hall measurements

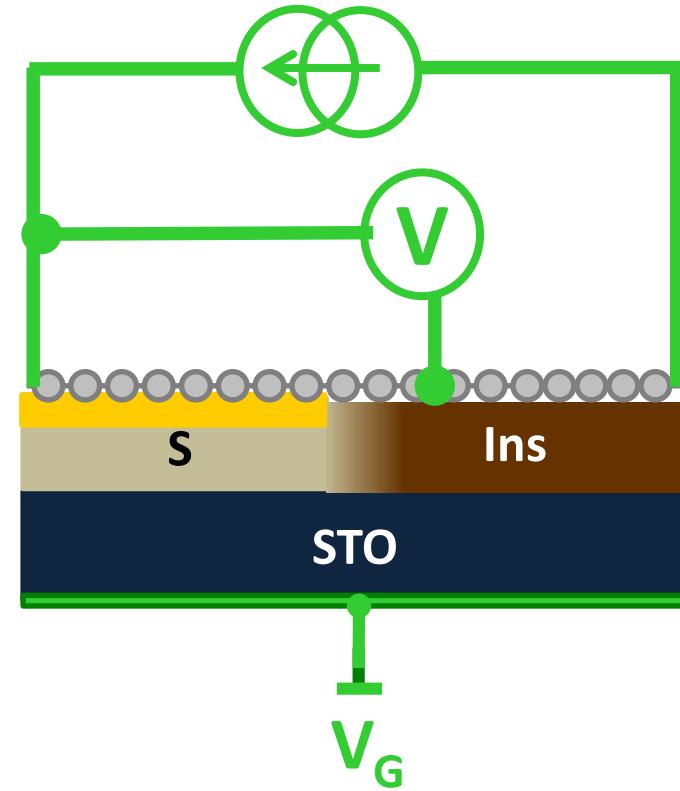
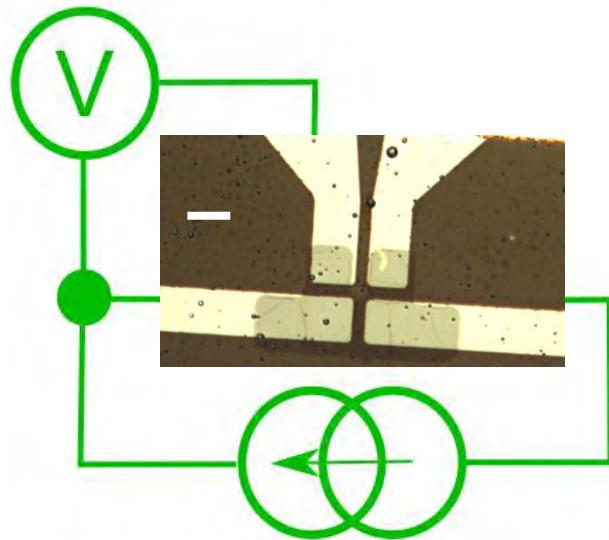


$$n = \frac{1}{e} \frac{\partial B}{\partial R_{xy}} \sim 10^{13} \text{ cm}^{-2}$$

$$E_F = \hbar v_F k = \hbar v_F \sqrt{\pi n}$$

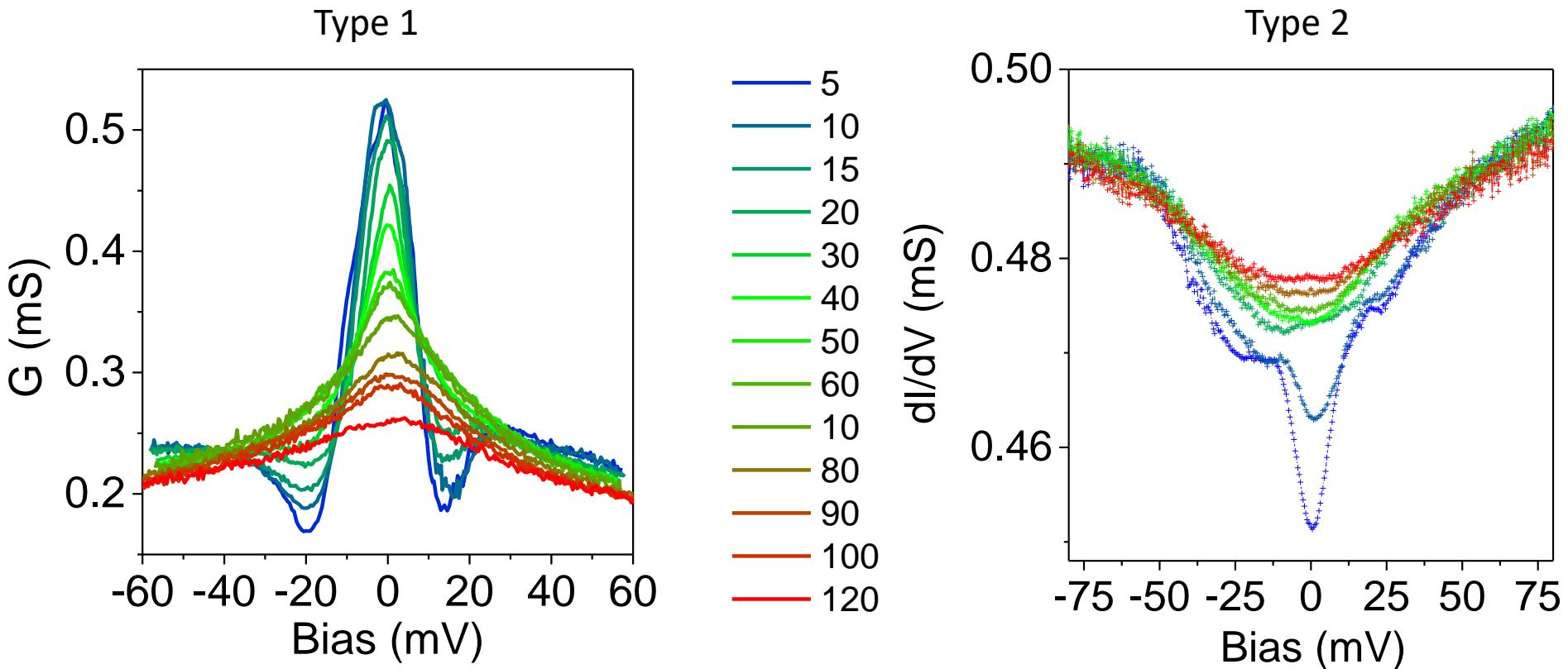
→ VERY FAR FROM DIRAC POINT
→ $E_F >> \Delta$

Measuring geometry



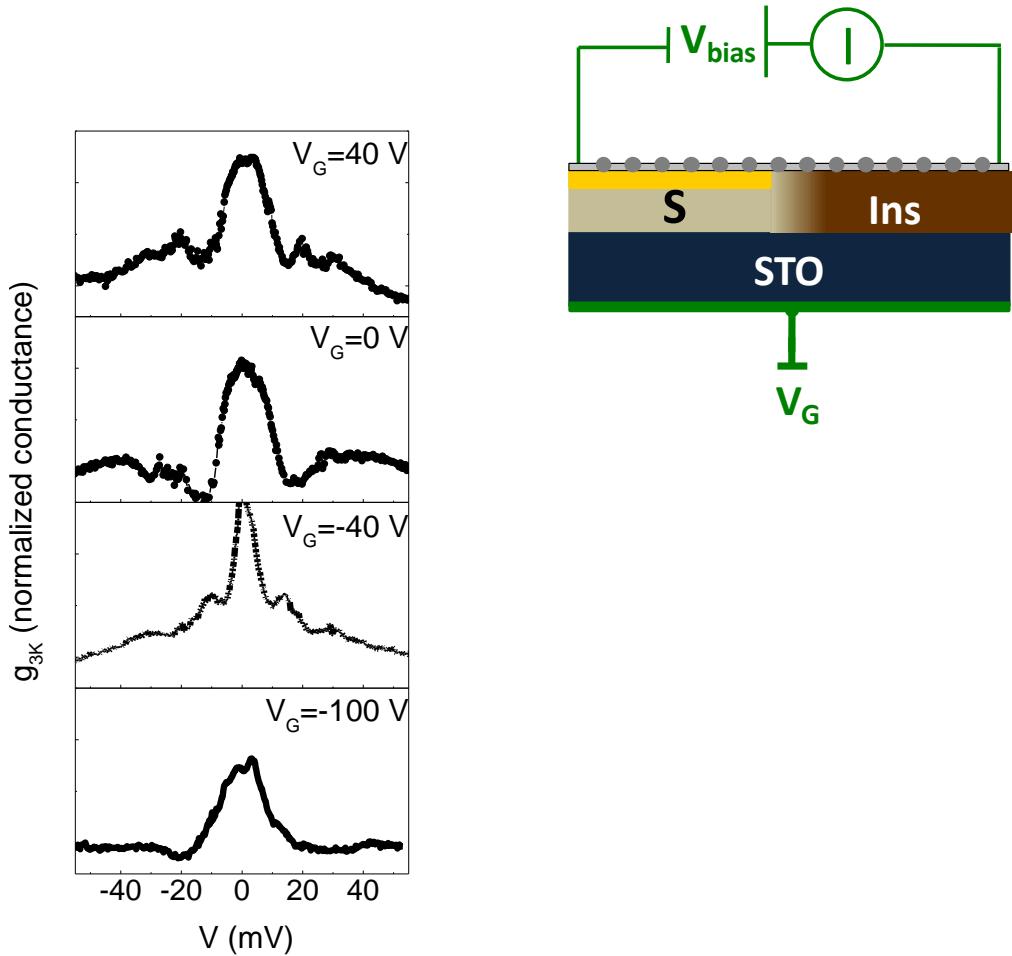
→ CONDUCTANCE GRAPHENE/S - GRAPHENE/N

Temperature dependent conductance



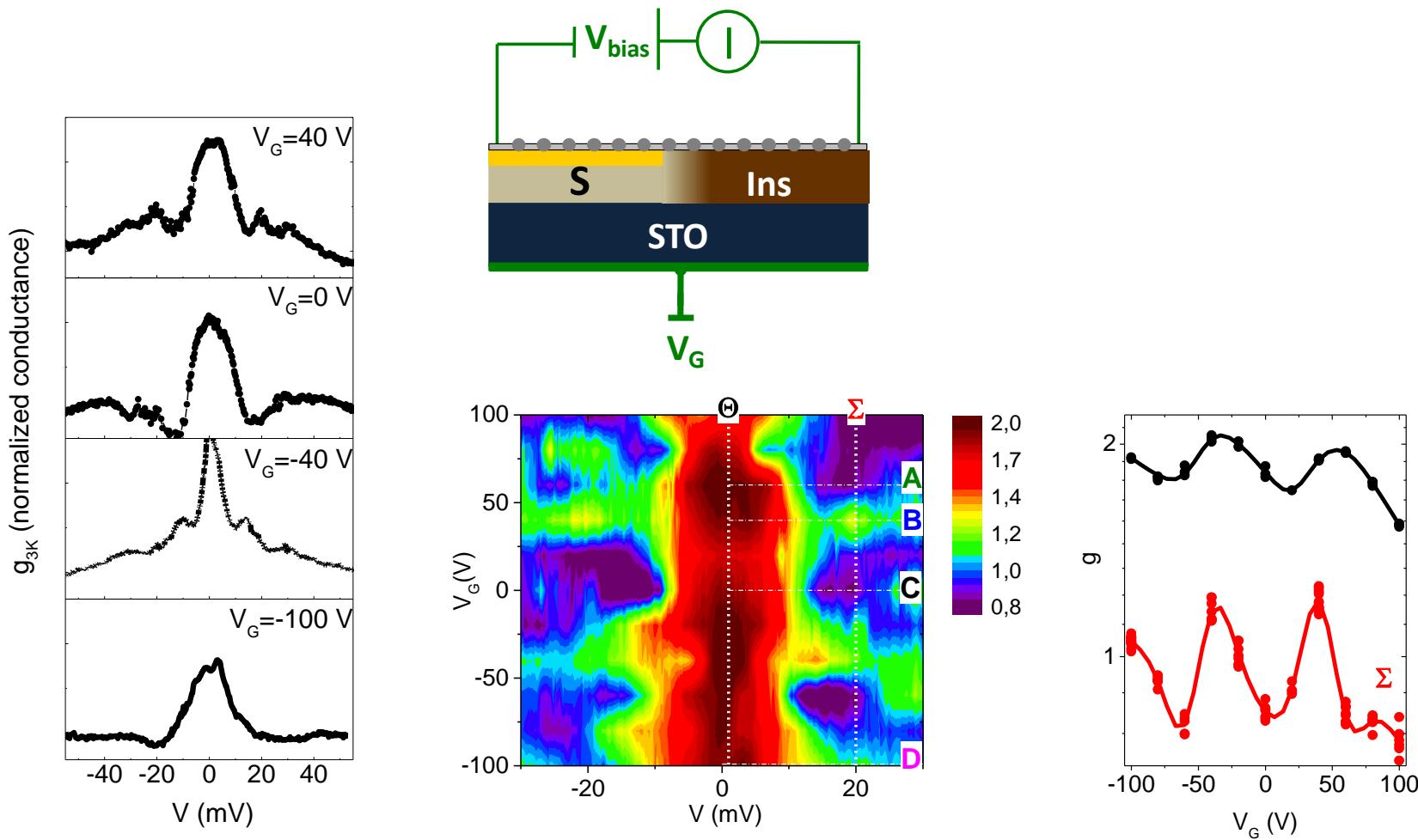
→ SAMPLE-DEPENDENT INTERFACE TRANSPARENCY

Gate dependent conductance



→ PERIODIC MODULATION OF CONDUCTANCE

Gate dependent conductance



→ PERIODIC MODULATION OF CONDUCTANCE

Theoretical grounds

PHYSICAL REVIEW B 77, 064507 (2008)

Tunneling conductance in *s*- and *d*-wave superconductor-graphene junctions: Extended Blonder-Tinkham-Klapwijk formalism

Jacob Linder and Asle Sudbø

Department of Physics, Norwegian University of Science and Technology, N-7491 Trondheim, Norway

(Received 21 August 2007; revised manuscript received 1 November 2007; published 14 February 2008)

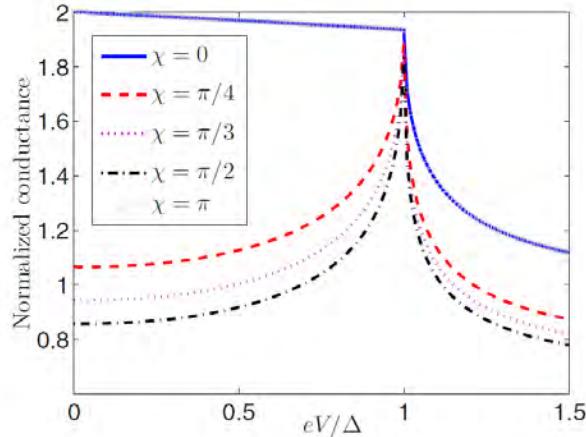


FIG. 11. (Color online) Conductance spectra for a N-I-S graphene junction with $E'_F/\Delta = E_F/\Delta = 100$, using *s*-wave pairing. We reproduce the same results as Ref. 12 with a π periodicity in the parameter χ . However, we obtain a phase shift of $\pi/2$ in χ compared to their results. We believe that this difference pertains to a minor sign error in the wave functions used in Ref. 12.

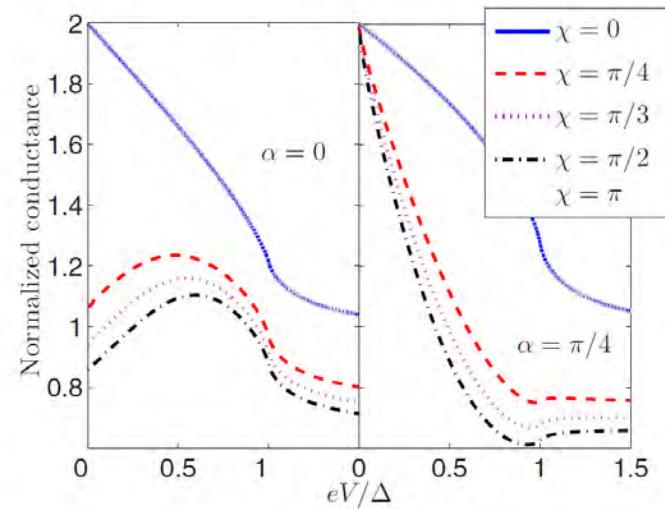
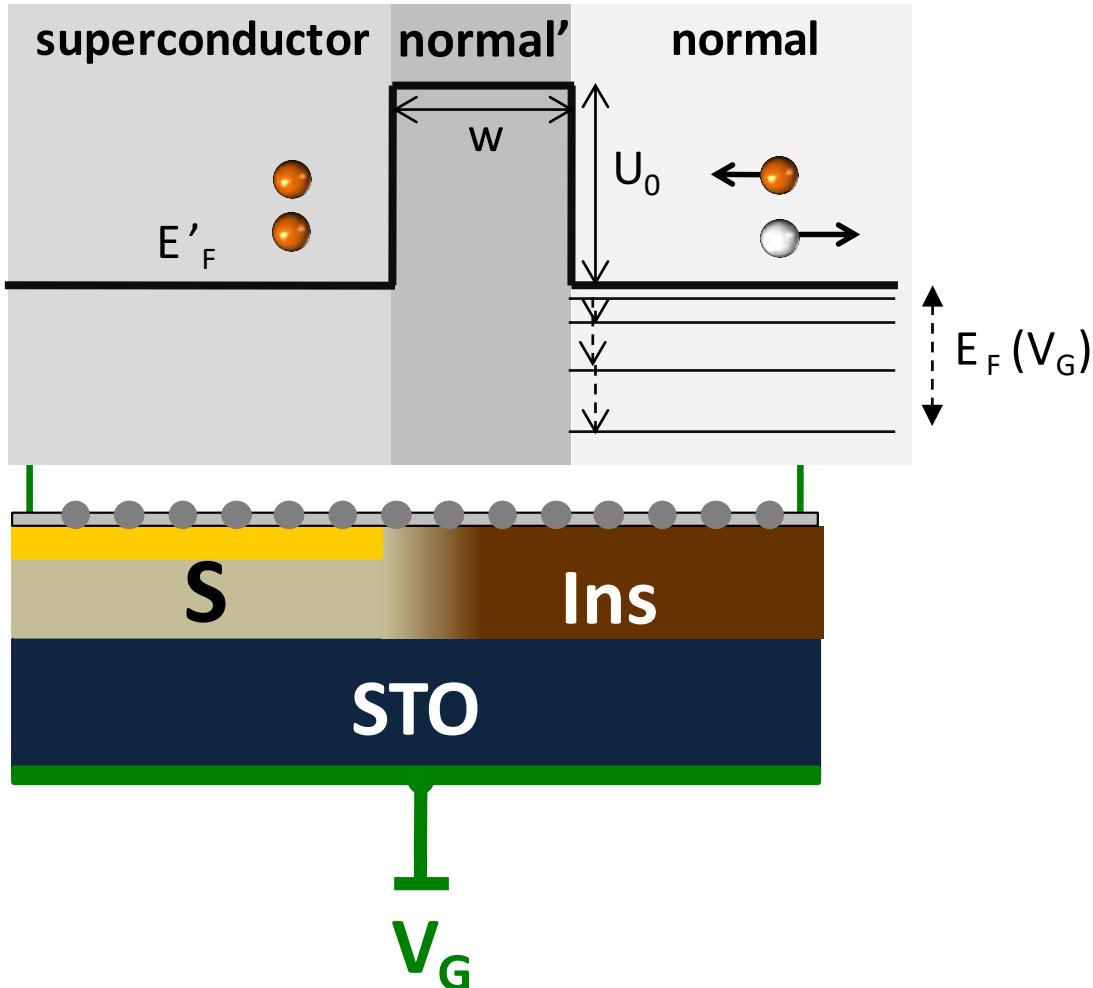


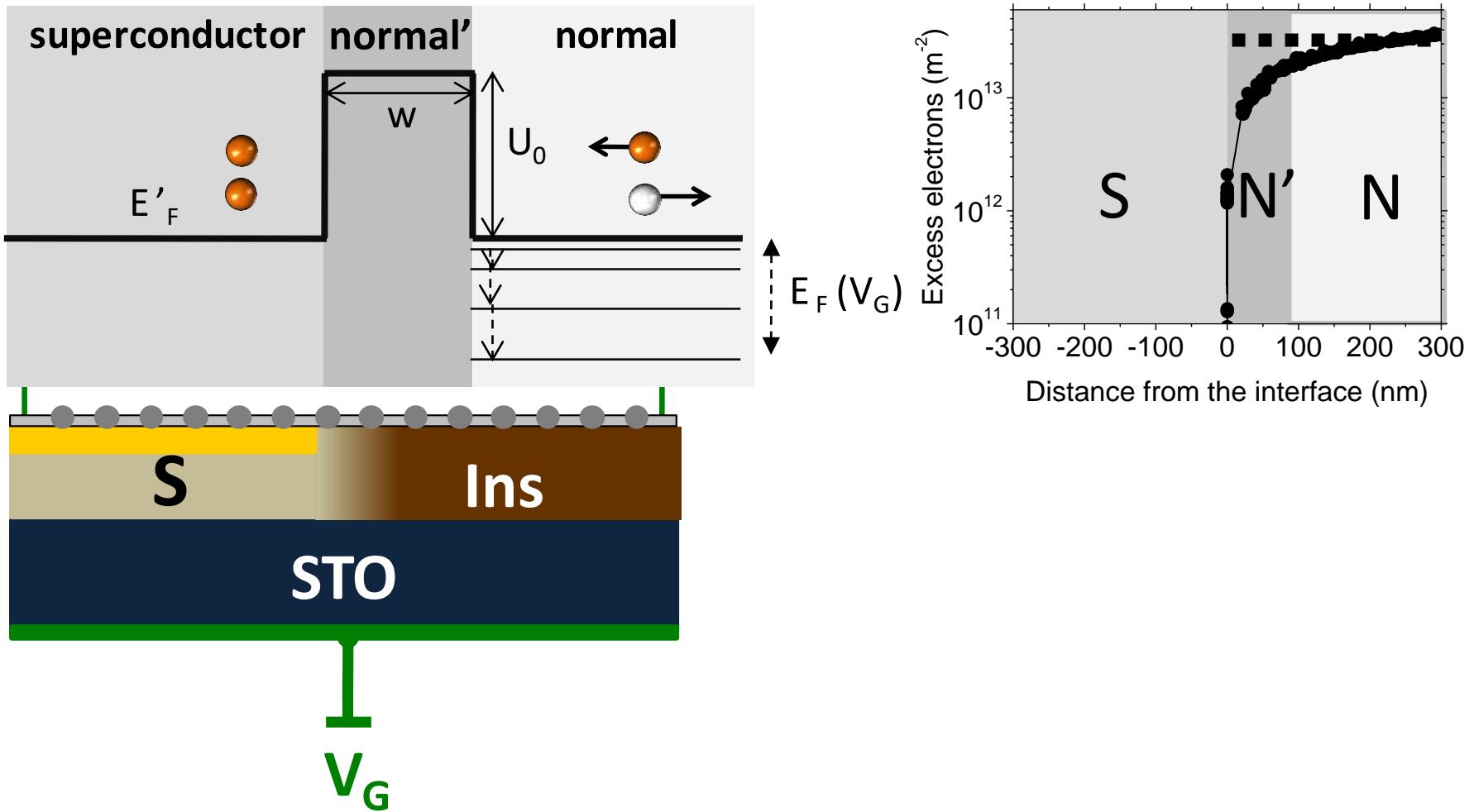
FIG. 13. (Color online) Conductance spectra for a N-I-S graphene junction with $E'_F/\Delta = E_F/\Delta = 100$, using *d*-wave pairing.

Superconducting / normal graphene interface model

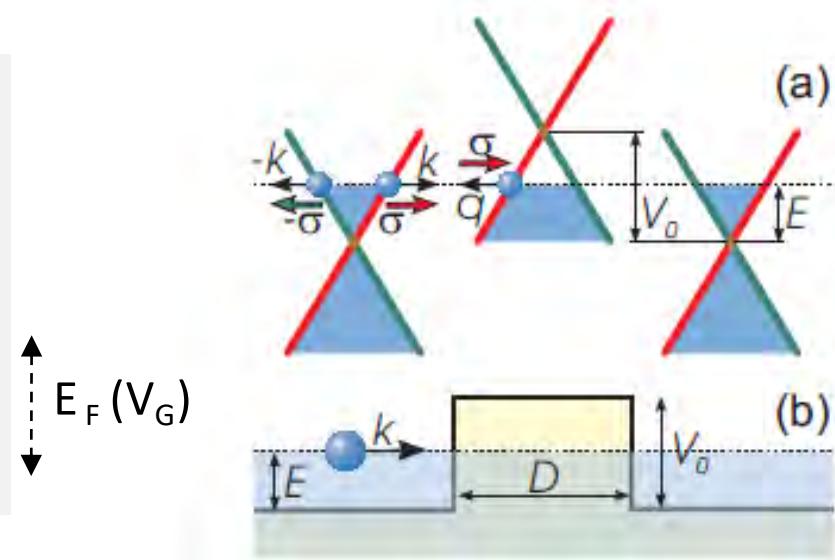
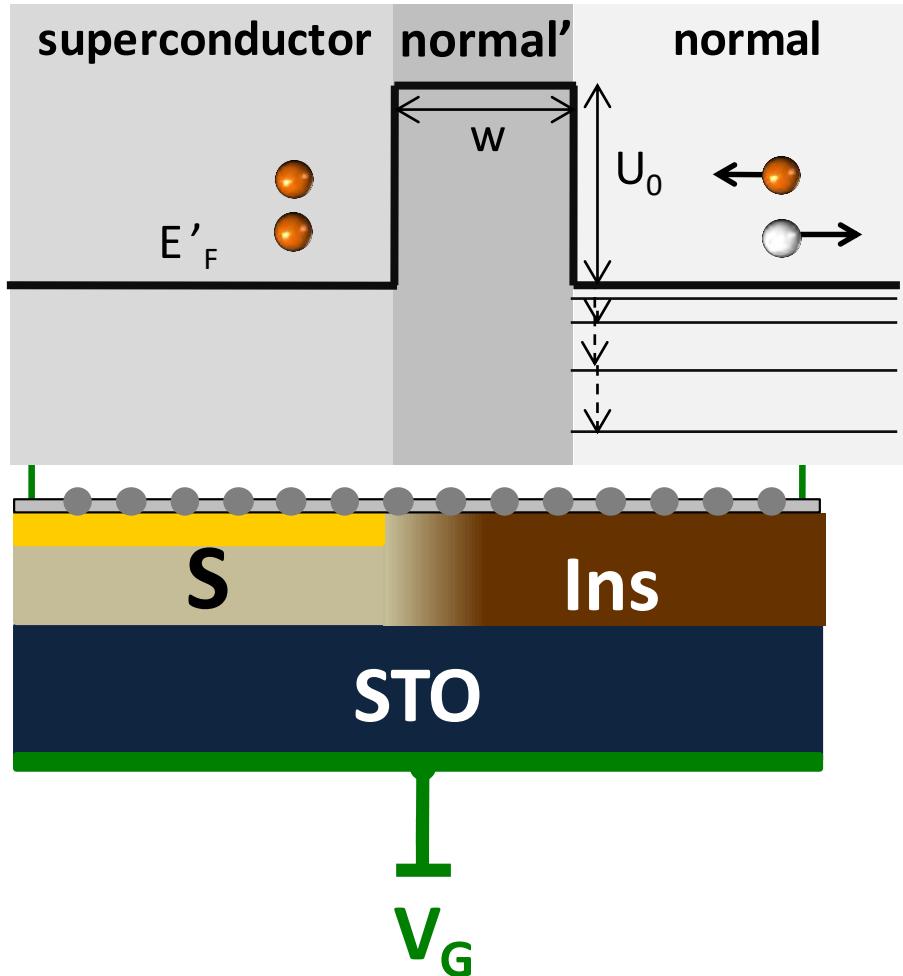


- ELECTRON/HOLE INTERFERENCE EFFECTS
- BARRIER U_0 SETS FERMI WAVELENGTH

Superconducting / normal graphene interface model



Superconducting / normal graphene interface model



Katsnelson *et al.* Nat. Phys (2006)

$$\chi = -w k_F = n \pi$$

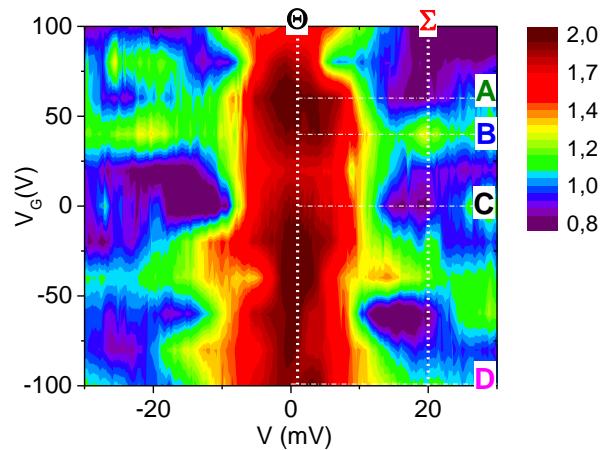
$$\chi = w(E_F - U_0)/\hbar v_F$$

Linder *et al.* PRB (2008)

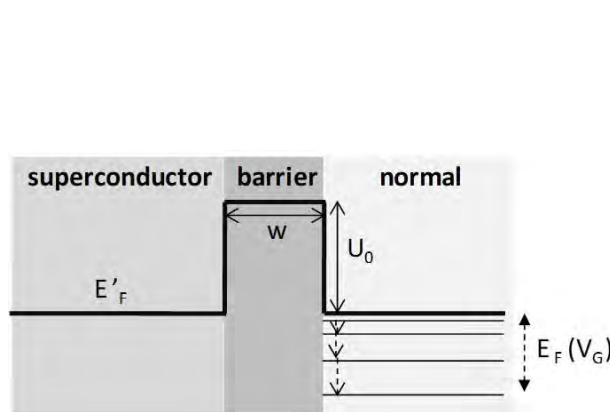
- ELECTRON/HOLE INTERFERENCE EFFECTS
- BARRIER U_0 SETS FERMI WAVELENGTH

Model simulations

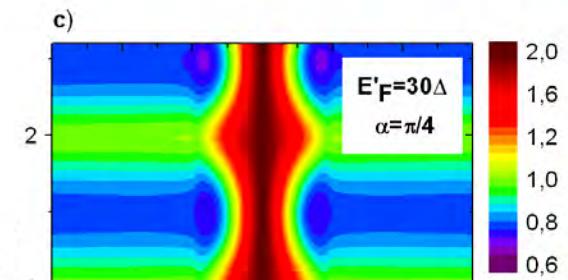
Experiment



Theory



Linder *et al.* PRB (2008)

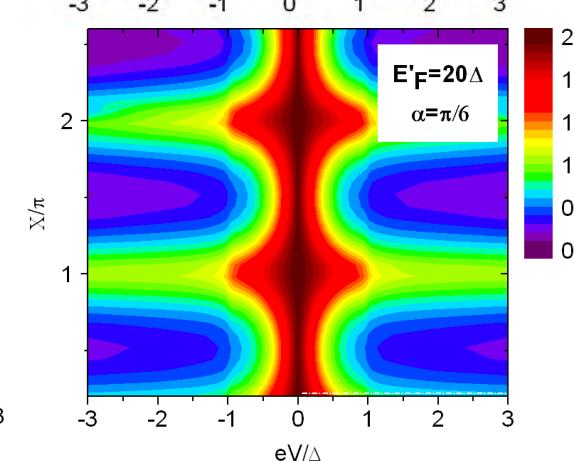
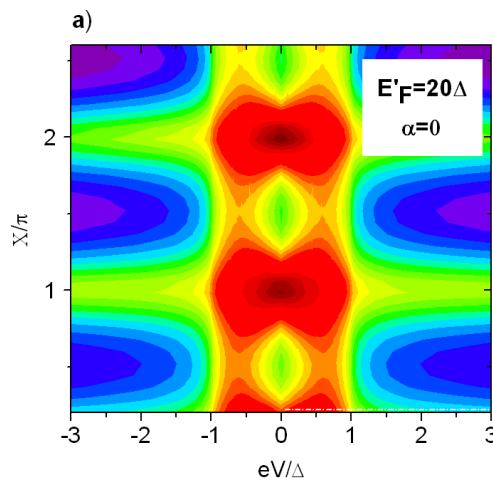


KNOWN

- $E_F(V_G)$ $\Delta \sim 20 \text{ mV}$
- $\delta\chi/\delta E_F \sim 3\pi/100$
- $w = \hbar v_F \delta\chi/\delta E_F = 60 \text{ nm}$

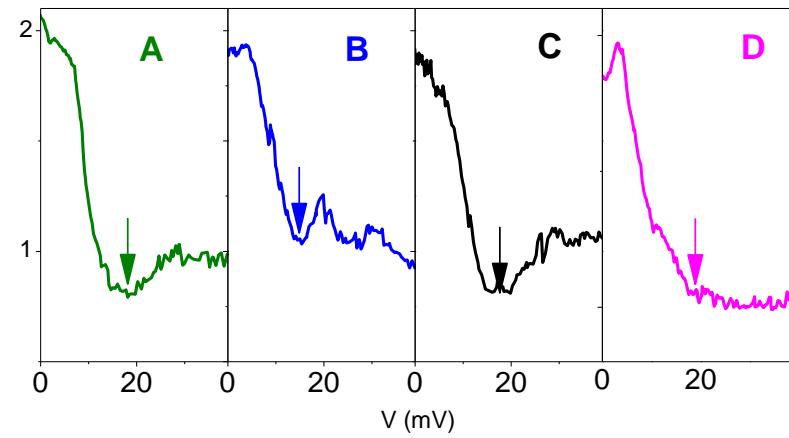
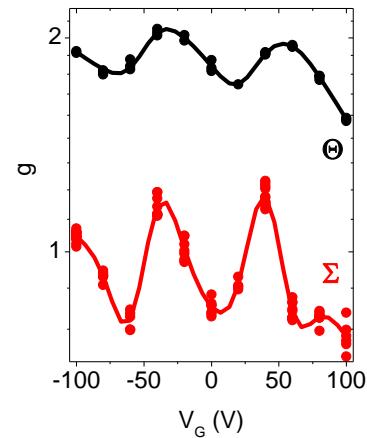
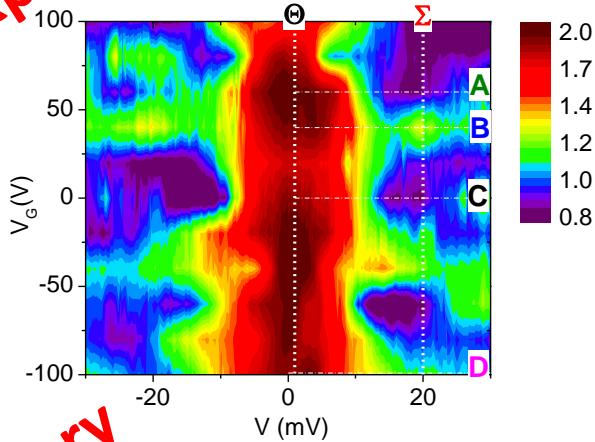
FREE

- E'_F
- α

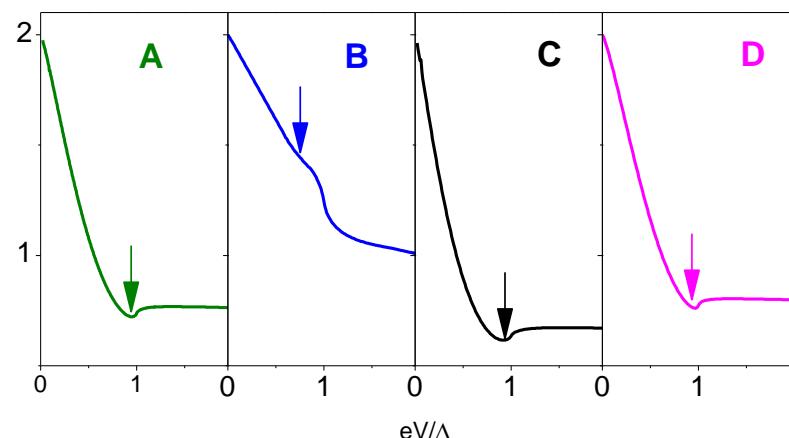
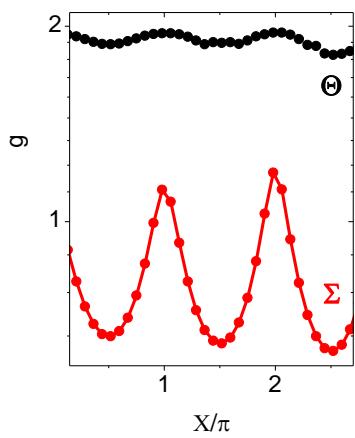
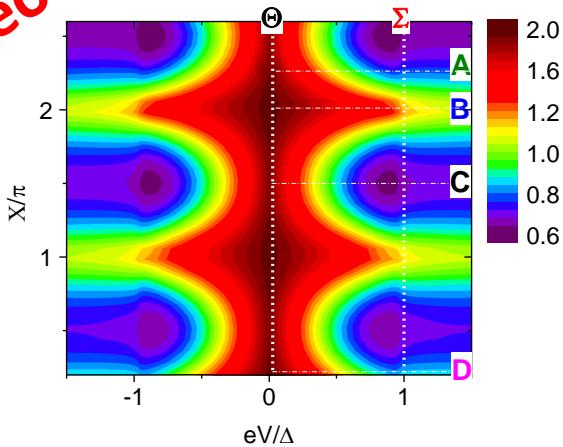


Theory vs. experiment

Experiment

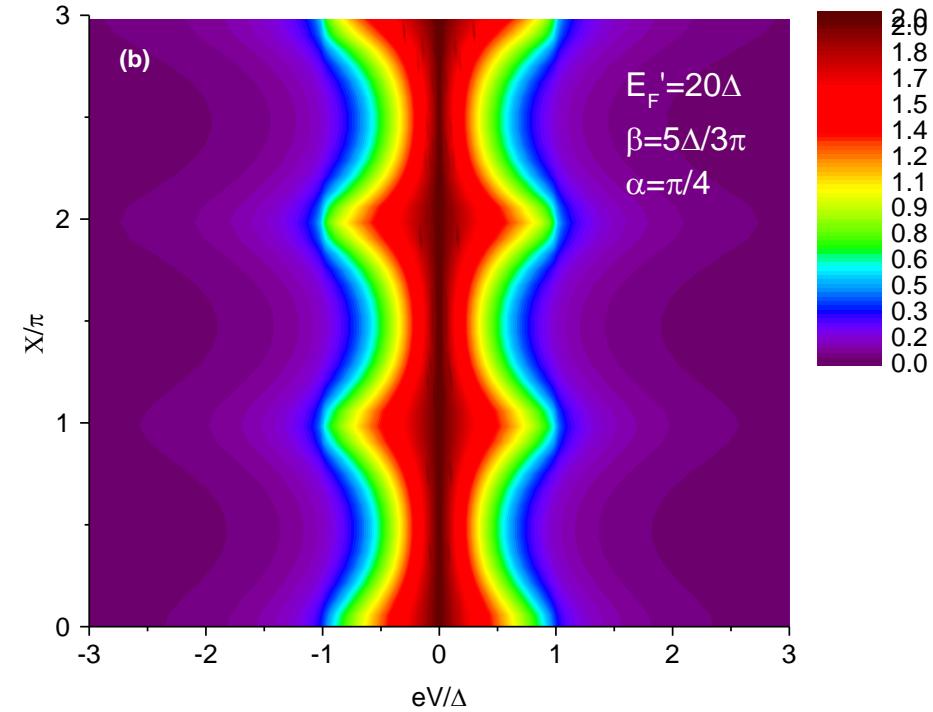
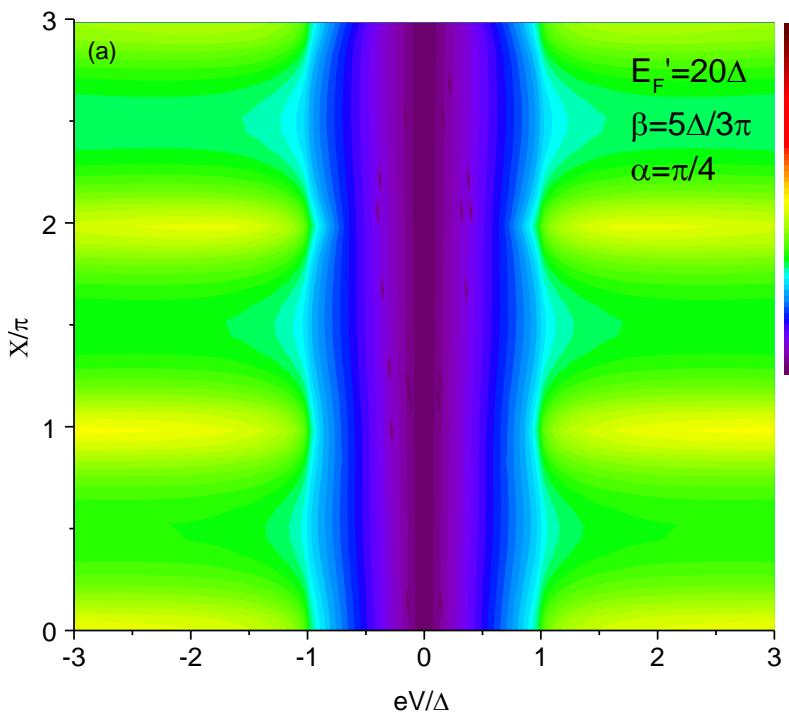


Theory



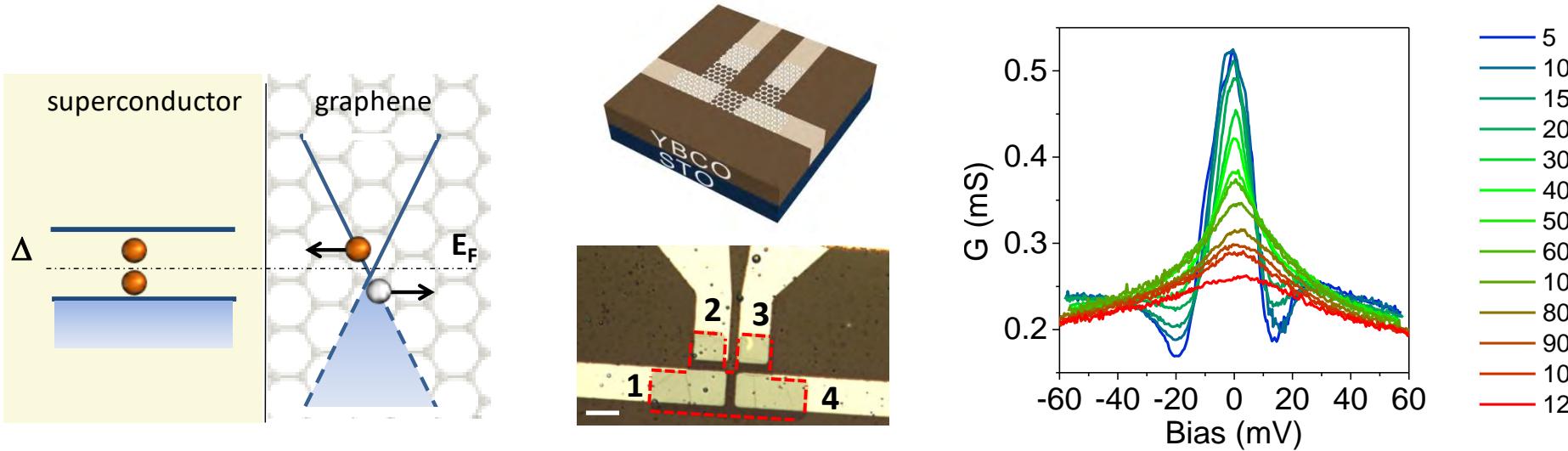
$$E'_F = 0.4 \text{ eV} \quad \alpha = \alpha/4$$

Gate tuning of superconducting carriers



→ FRACTION OF SUPERCARRIERS TUNABLE BY GATING

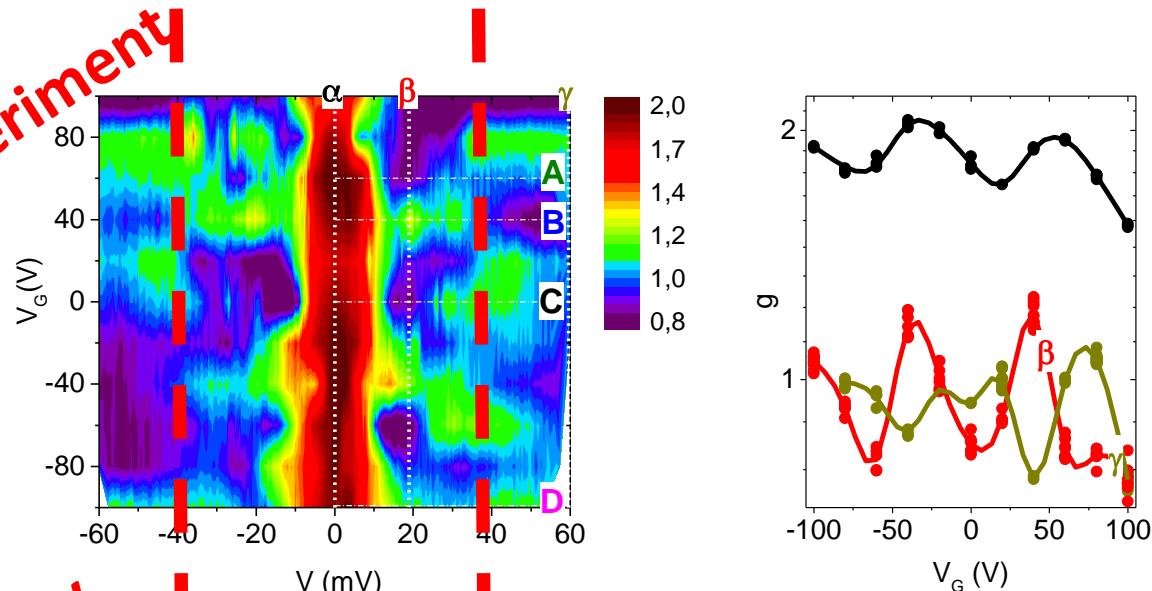
Conclusions



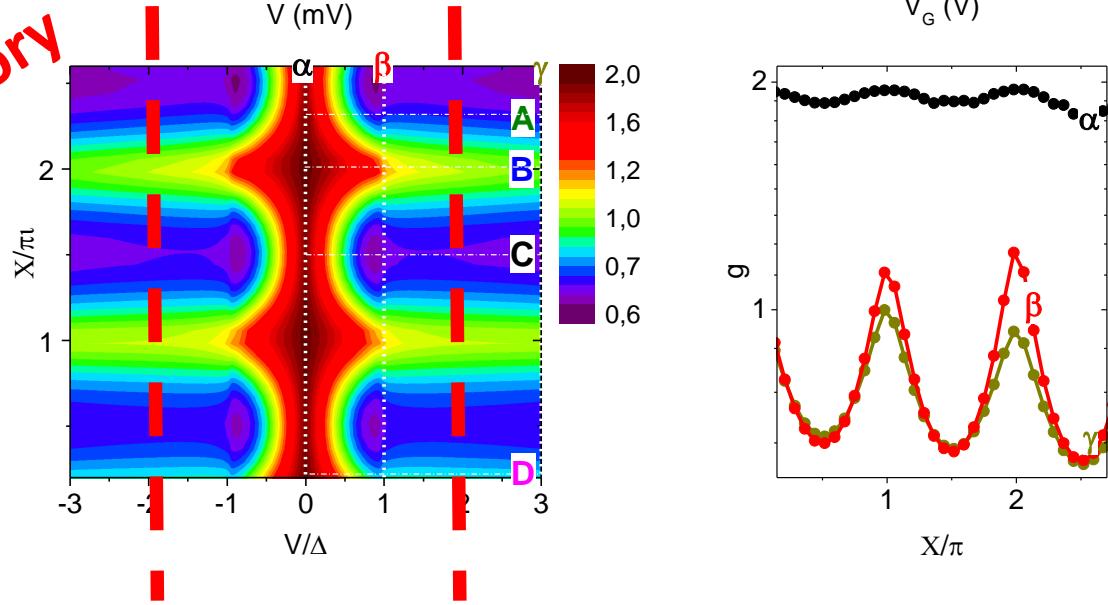
- HIGH- T_c SUPERCONDUCTOR / GRAPHENE DEVICES
- GATE TUNABLE PROXIMITY IN CVD GRAPHENE
- ROBUST QUANTUM INTERFERENCE EFFECTS

Theory vs. Experiment disagreement

Experiment



Theory



A



EUROPEAN COOPERATION
IN SCIENCE & TECHNOLOGY



NANOSCALE COHERENT
HYBRID DEVICES
FOR SUPERCONDUCTING
QUANTUM TECHNOLOGIES



Funded by the Horizon 2020 Framework Programme
of the European Union

http://www.cost.eu/COST_Actions/ca/CA16218

- €€ for short term visits
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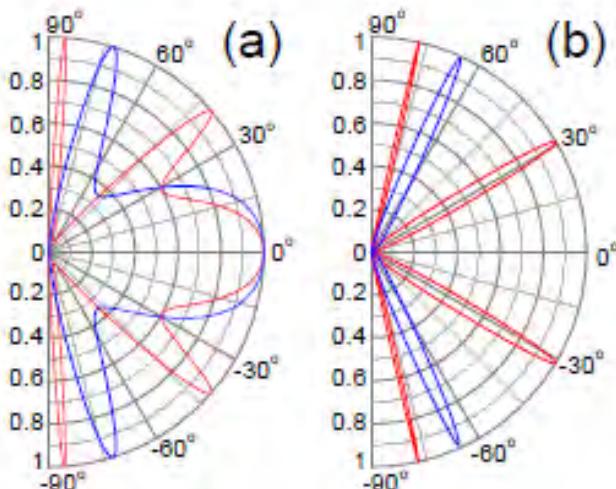


FIG. 2: Klein-like quantum tunneling in graphene systems. Transmission probability T through a 100-nm-wide barrier as a function of the incident angle for (a) single- and (b) bi-layer graphene. The electron concentration n outside the barrier is chosen $0.5 \times 10^{12} \text{ cm}^{-2}$ for all cases. Inside the barrier, hole concentrations p are 1×10^{12} and $3 \times 10^{12} \text{ cm}^{-2}$ for red and blue curves, respectively (such concentrations are most typical in experiments with graphene). This corresponds to the Fermi energy E of incident electrons ≈ 80 and 17 meV for single- and bi-layer graphene, respectively, and $\lambda \approx 50 \text{ nm}$. The barrier heights V_0 are (a) 200 and (b) 50 meV (red curves) and (a) 285 and (b) 100 meV (blue curves).

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Dielectric properties of sputtered SrTiO₃ films

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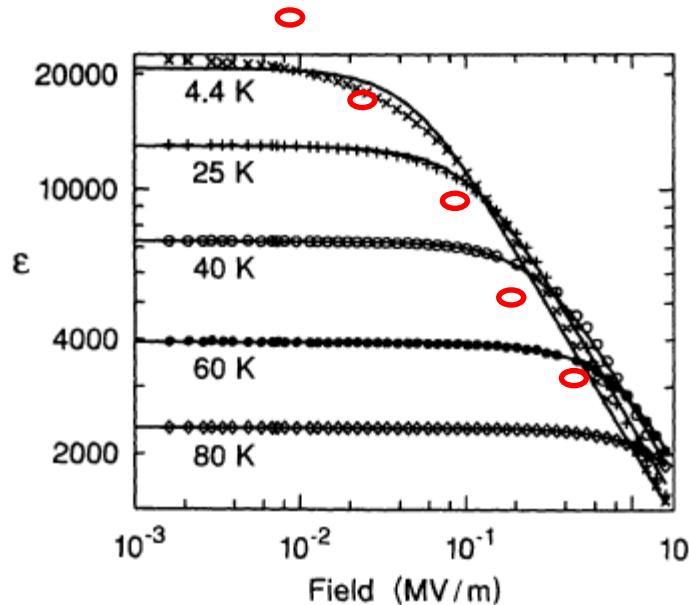


FIG. 2. Field dependence of the dielectric constant ϵ of single-crystal SrTiO₃ at various temperatures. Solid lines are fits to Eqs. (3) and (4).

$$\begin{aligned}\epsilon_{STO} &\sim 10^4 \quad d_{STO} = 500 \text{ } \mu\text{m} \\ \epsilon_{STO} &\sim 10^4 \quad d_{YBCO} = 50 \text{ nm}\end{aligned}$$

$$\frac{\delta n}{\delta V_G} = \epsilon_0 \left[\left(\frac{d_{STO}}{\epsilon_{STO}} + \frac{d_{YBCO}}{\epsilon_{YBCO}} \right) 2e \right]^{-1}$$

$$\frac{\delta n}{\delta V_G} \sim 5 \cdot 10^{10} \text{ (cm}^{-2}\text{V}^{-1}\text{)}.$$



Josephson current and multiple Andreev reflections in graphene SNS junction

ELEMENTARY EXCITATIONS IN THE VICINITY OF
A NORMAL METAL-SUPERCONDUCTING METAL CONTACT

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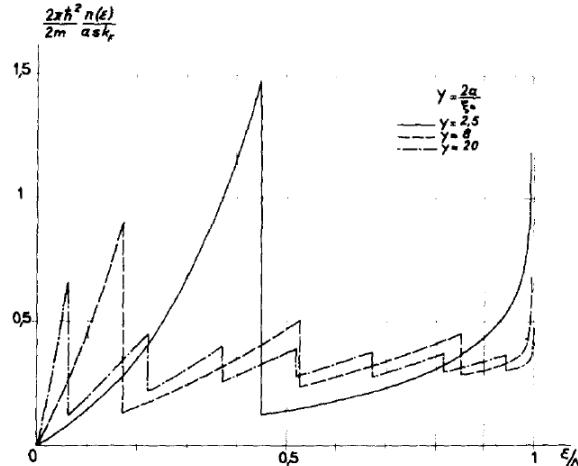
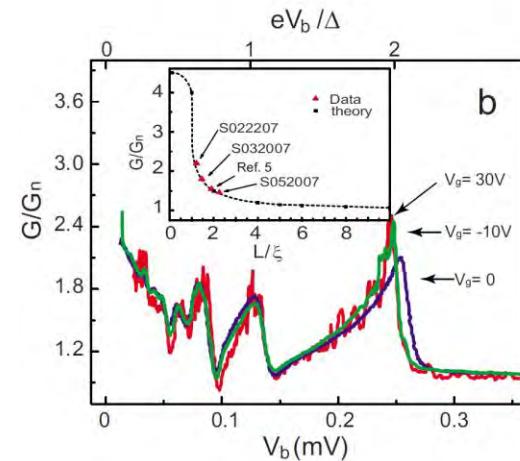
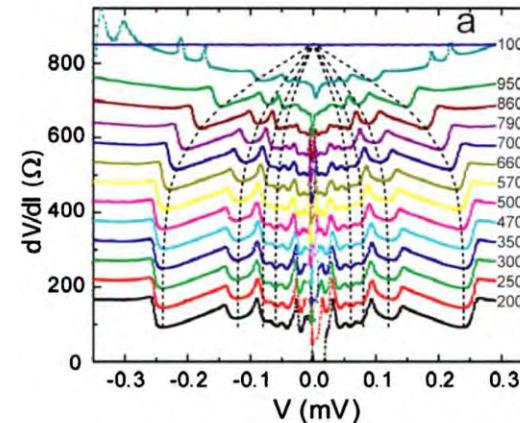


Fig. 1. Density of states.

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Proximity Effect in Gold-Coated $\text{YBa}_2\text{Cu}_3\text{O}_{7-\delta}$ Films Studied by Scanning Tunneling Spectroscopy

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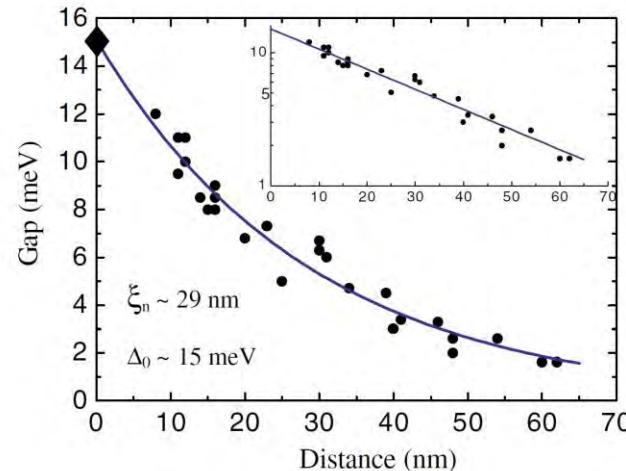


FIG. 3 (color online). Measured gap size as a function of distance from the N-S interface (solid circles). The distance is estimated from the distance to the crystallite edge, measured from the STM topographic images, taking into account the nominal Au film thickness. The solid line is a fit to a decaying exponential form, with normal coherence length (penetration depth) $\xi_N \approx 29$ nm, and interface gap value $\Delta_0 \approx 15$ meV (the diamond symbol). The inset shows the data in a semilog scale.